

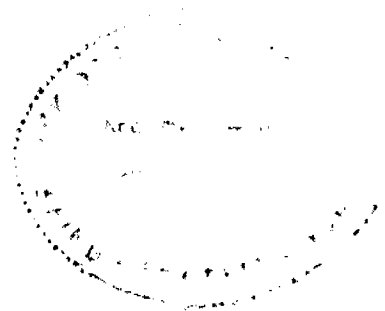
# **RELIABILITY EVALUATION OF ELECTRONIC CIRCUITS**

**A DISSERTATION**

submitted in partial fulfilment of  
the requirements for the award of the degree  
of  
**MASTER OF ENGINEERING**  
in  
**ELECTRICAL ENGINEERING**  
(With Specialization in System Engineering & Operations Research)

By

**DEBASISH BASAK**



**DEPARTMENT OF ELECTRICAL ENGINEERING  
UNIVERSITY OF ROORKEE  
ROORKEE-247667 (INDIA)**

**April, 1988**

TO MA & BABA

CANDIDATE'S DECLARATION


I hereby certify that the work which is being presented in the dissertation entitled, 'RELIABILITY EVALUATION OF ELECTRONIC CIRCUITS', in partial fulfilment of the requirements for the award of the degree of MASTER OF ENGINEERING in ELECTRICAL ENGINEERING with specialization in SYSTEM ENGINEERING AND OPERATIONS RESEARCH, submitted in the Department of Electrical Engineering, University of Roorkee, Roorkee, is an authentic record of my own work carried out during the period from August 1987 to March 1988 under the supervision of Dr. J.D.Sharma, Professor, Department of Electrical Engineering, University of Roorkee, Roorkee, India.

The matter embodied in this dissertation has not been submitted by me for the award of any other degree or diploma.

Dated: April 13, 1988

*Debasish Basak*  
(DEBASISH BASAK)

This is to certify that the above statement made by the candidate is correct to the best of my knowledge.

  
[J.D.SHARMA]  
Professor  
Department of Elect.Engg. ,  
University of Roorkee  
Roorkee-247667, India

ABSTRACT

The complexity of electronic circuits has increased rapidly with the advancement of integrated circuit technology. A detailed study of electronic circuit design is thus necessiated prior to its fabrication. Reliability evaluation of the circuits is the most urgent step in the design process.

An effort has been made to evaluate the component failure rate of electronic circuits with database structures of failure rate data. Part stress analysis technique is adopted to quantify the part failure models of different components in the circuit. The loading (electrical stress) of each component is calculated from the circuit analysis (d.c. and transient behaviour of the circuit). A menu-driven program is written using dBASE III PLUS package to calculate the part failure rates. The electrical stress (loading) and other factors (like temperature, environment, parts quality etc.) are the inputs to the program written. Since the program is menu-driven, all the required inputs, for a particular component selected can be displayed on C.R.T. terminal. Finally, the total failure rate of the circuit is stored in a database structure and can be obtained in any desired report form. It is assumed that failure of any component will cause the failure of the circuit.

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(DEBASISH BASAK)

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## CHAPTER - I

### INTRODUCTION

Considerable interaction between the circuit elements of the modern complex electronic circuits arises due to higher speed and frequency and miniaturization. It necessitates to perform an elaborate study of circuit design prior to fabrication. The circuit design process may be classified into following separate but interacting phases:

- (i) feasibility study - consisting of initial structure of the circuit with satisfied loose specifications.
- (ii) preliminary design phase - consisting of tighter design specifications with optimal choice of design-able parameters using appropriate circuit analysis topology.
- (iii) detailed design phase - consisting of physical design with detailed component specifications and reliability studies.

The flow chart for the electronic circuit design is shown in Fig. 1.1.

Initial structure of the circuit is made first and this structure lists the components necessary for circuit implementation and their functional relationships. Whether certain loose specifications are satisfied or not is now tested. Some methods of circuit analysis and computer

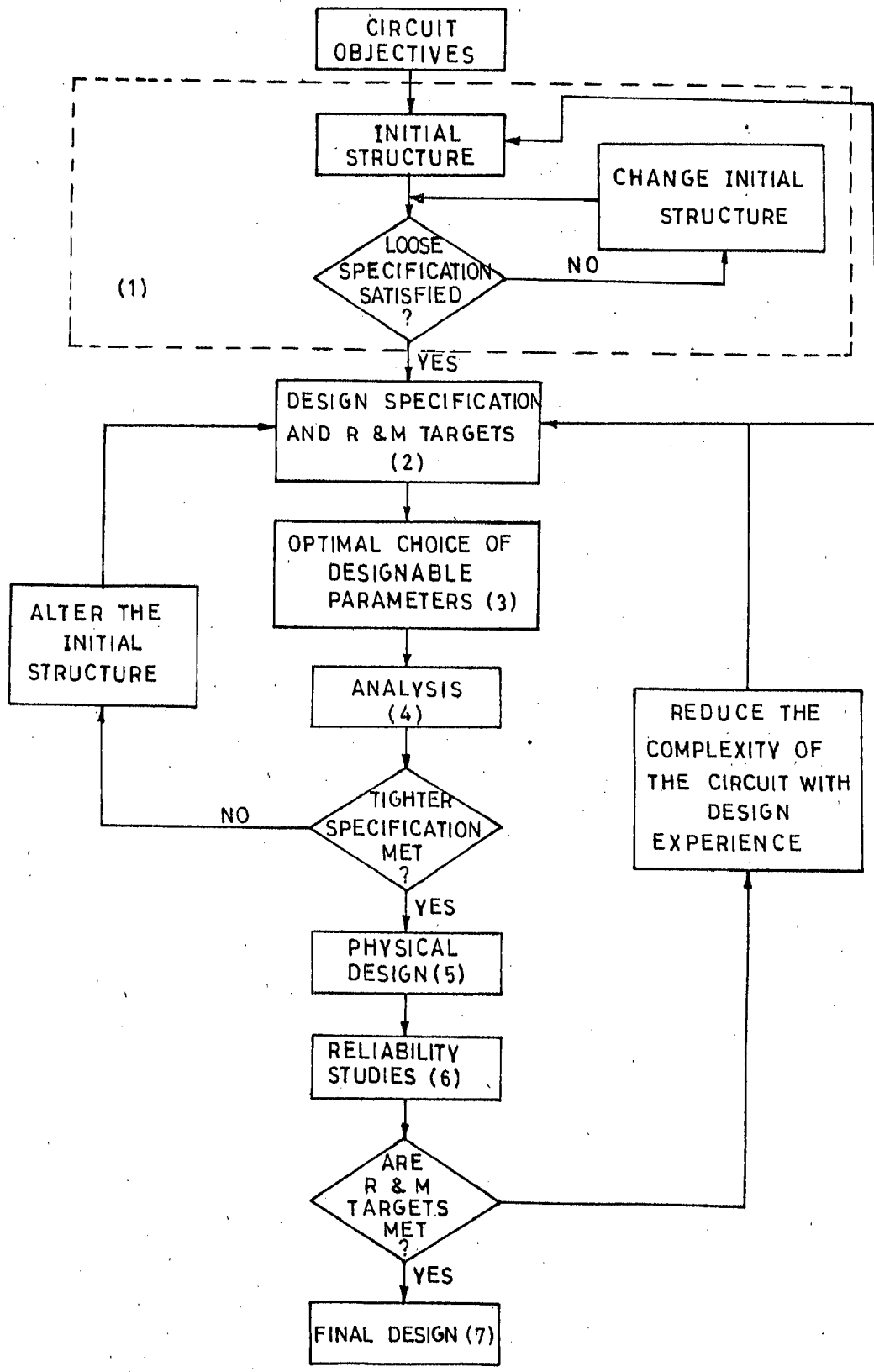


FIG.1-1-ELECTRONIC CIRCUIT DESIGN PROCESS

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simulation are involved in this process and is continued until the loose specification satisfies the designer from technological ability, skill and past experience.

A set of tighter and complete design specifications, incorporating operating characteristics under normal and abnormal conditions, reliability, physical realizability, dimension requirement and economic soundness, are defined. The designer now optimizes the circuit by varying the designable parameters to achieve the desired specifications. If the design specification is not satisfied by varying the circuit parameters, then the topology of the circuit is altered and the previous design steps are repeated, otherwise next step is followed.

Now comes the physical design of the circuit which determines the mechanical layout of circuit on the printed circuit board, suitable for production with the electrical and physical constraints.

Reliability evaluation of the circuit is the next very important step in design. Reliability analysis of the circuit is required to have an estimate of the theoretically achievable reliability, availability and to point out the areas of high-failure rate concentration in the circuit. These areas of high failure rates may be eliminated by judicious use of redundancy techniques, using highly reliable components or by reducing the circuit complexity.

Reliability can be assessed precisely in the design process. But some divergences are always expected. The component failure rate data are seldom precise and tests show the deviations caused by divergences between actual and expected operating conditions, such as temperature, environment, loadings of components etc. Total part reliability can be implicitly determined during design process of an electronic circuit. Therefore, it is essential to have a tool which successfully measures the reliability. The tool is obviously the failure rate prediction system based on the physical properties of components.

Out of the two methods, Parts Count and Part Stress Analysis, the latter is more accurate as it takes into account all the factors (electrical stress, temperature, environment etc.) which are responsible for a part failure.

The different analytical part failure models for different part types are available in MIL-HDBK-217D. The field data are recorded in that book to calculate the different factors in the part failure rate models. Before using these factors, loading of each component on an electronic circuit is necessary as it affects the base failure rate of the component. Loadings can only be obtained when the non-linear circuit equations, representing relations between component parts in terms of voltages or currents, are solved. The circuit analysis [20,21] is utilized to find out the loading of each component in the circuit.

In this dissertation, a software is developed for reliability evaluation of electronic circuits. At first database structures are designed. Failure rate data for different components (resistors, capacitors, transistors & diodes) are stored in these database files. The structure of database files for these components are listed in Appendix B. A menu-driven program using dBASE III PLUS package has been written to evaluate the reliability of the electronic circuits in terms of failure rate (no. of failures/ $10^6$  hour) utilizing Part Stress analysis technique. The loadings of constituent components of the circuit as determined in the circuit analysis have been combined with other input factors in this program to evaluate the electronic circuits. It has been assumed that the specified circuit will fail when any one of its components fail and failure rate of the circuit is equal to the sum of the failure rates of its components [ 17, 22, 34 ].

## chapter 2

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## CHAPTER - II

### BASIC RELIABILITY THEORY AND APPLICATION

#### 2.1 INTRODUCTION

The reliability of a complex circuit depends on the reliability of its components. The measure of a component's reliability is the frequency at which failures occur in a given time period. The useful failure pattern that can be anticipated for electronic components is shown in Fig. 2.1. Reliability distinguishes three characteristic types of failures (excluding damage caused by careless handling, storing or improper operation by users) which may be inherent in the electronic equipments and occur without any fault on the part of the operator [ 4, 15, 32, 34].

Initially, the item population exhibits a high failure rate. This failure rate decreases rapidly during this first period (often called the "infant mortality", "burn-in" or debugging period), and stabilizes at an approximate value (at time  $T_B$ ) when the weak units have died out. It may be caused by manufacturing deviations from the design intent, transportation damage or installation errors. This is usually pronounced in new equipment. Many of these early failures can be prevented by improving the control over manufacturing process.

The item population, after having been burned-in,



~~The~~ level, which is normally  
~~by~~ constant failure rate, accom-  
~~pany~~ gradual changes due to wear.

$T_B$  and  $T_W$  in Fig. 2.1) is called  
~~is~~ characterized mainly by the  
~~caused~~ by sudden stress accumulations  
~~in~~ of the component. The exponential  
~~is~~ widely used as a mathematical model  
~~is~~ period which is the most signifi-  
~~is~~ ability prediction and assessment acti-  
~~is~~ components, it is found that excessive  
~~is~~ age levels, either steady-state, transient  
~~is~~ and rates, are the two most destructive  
~~is~~ vibration, shock and altitude contri-  
~~is~~ of design strength devices.

~~is~~ and final life period occurs when the item  
~~is~~ is the point where the failure rate starts  
~~is~~ ceably ( $T_W$ ). This point identifies the end  
~~is~~ or the start of wear out. Wearout failures  
~~is~~ of component aging.

#### ~~is~~ AL FAILURE MODEL

~~is~~ The characteristic curve shown in Fig. 2.1 can  
~~is~~ be defined by three failure components which pre-  
~~is~~ scribe the three periods of an item's life.  
~~is~~ Illustrates these components in terms of an

reaches its lowest failure rate level, which is normally characterised by a relatively constant failure rate, accompanied by negligible or very gradual changes due to wear. This second period (between  $T_B$  and  $T_W$  in Fig. 2.1) is called the useful life period, and is characterized mainly by the occurrence of failures caused by sudden stress accumulations beyond the design strength of the component. The exponential failure distribution is widely used as a mathematical model to approximate this time period which is the most significant period for reliability prediction and assessment activities. For electronic components, it is found that excessive temperature and voltage levels, either steady-state, transient or changing at rapid rates, are the two most destructive stresses. Humidity, vibration, shock and altitude contribute to the failure of design strength devices.

The third and final life period occurs when the item population reaches the point where the failure rate starts to increase noticeably ( $T_W$ ). This point identifies the end of useful life or the start of wear out. Wearout failures are a symptom of component aging.

## 2.2 EXPONENTIAL FAILURE MODEL

The life characteristic curve shown in Fig. 2.1 can be further defined by three failure components which predominate during the three periods of an item's life. Fig. 2.2 illustrates these components in terms of an

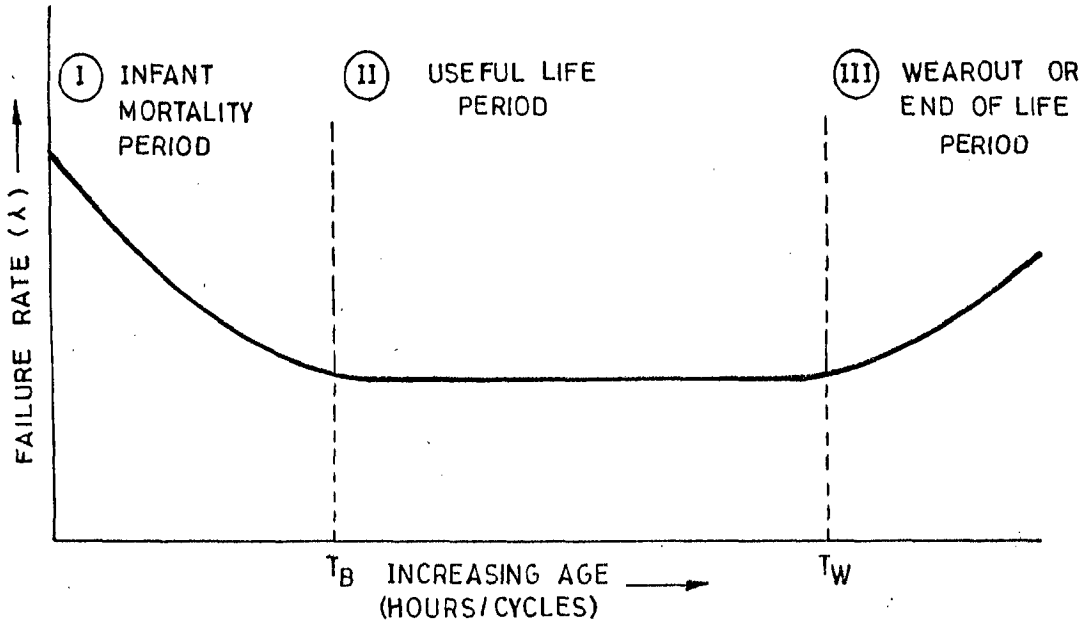


FIG.2-1-ELECTRONIC EQUIPMENT AND COMPONENTS FAILURE PATTERN

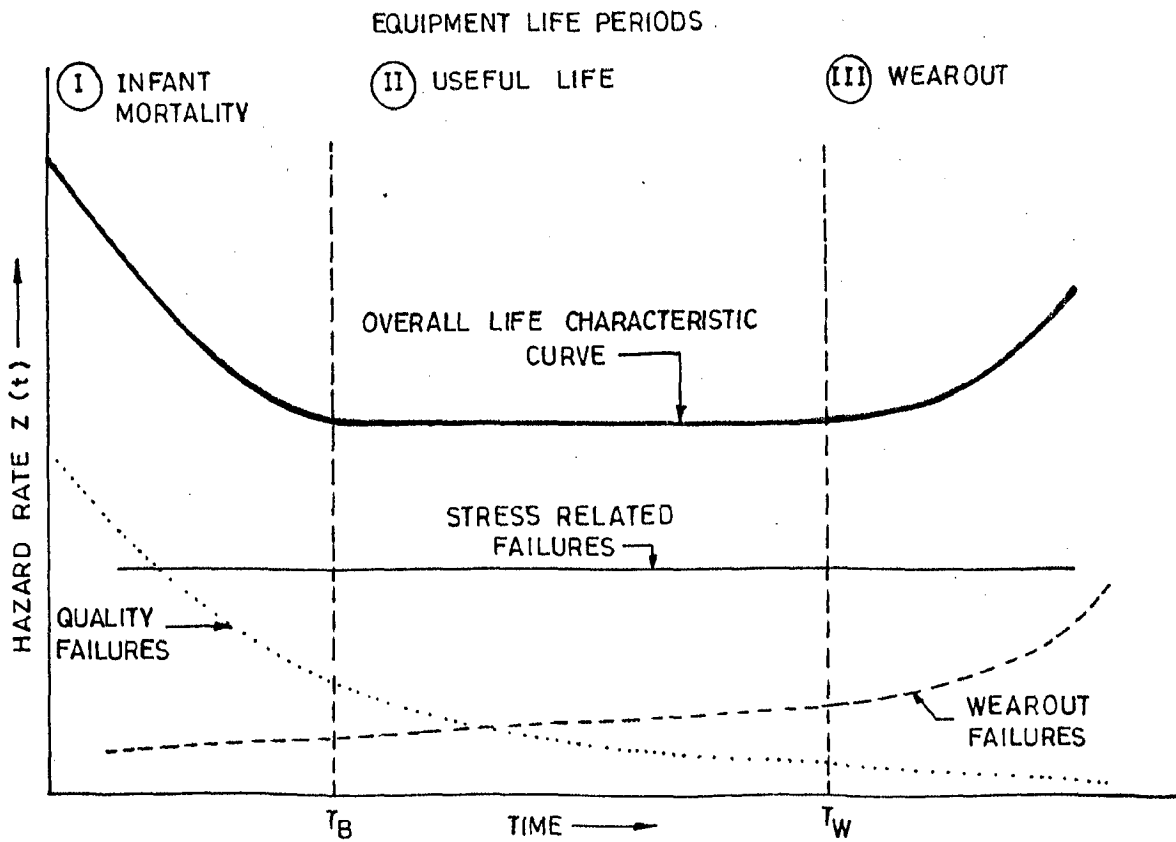


FIG.2-2-COMPONENTS OF FAILURE

equipment hazard rate,  $Z(t)$ , which is simply stated as the conditional probability of failure. The failure components shown in Fig. 2.2 include:

- (1) Early failure due to design and quality-related manufacturing defects and which have a decreasing hazard rate.
- (2) Stress related failure due to application stresses and which have a constant hazard rate.
- (3) Wearout failures due to aging and/or deterioration and which have an increasing hazard rate.

The combination of these three failure components in the infant mortality period characterizes a high but rapidly decreasing hazard rate. The combination results in a constant hazard rate in the useful life period because the decreasing quality failures and increasing wearout failures tend to offset each other, and because the stress related failures exhibit a relatively large amplitude. The wearout period is characterized by an increasing hazard rate.

The use of this type of "failure law" for complex electronic systems can be explained in the following ways:

- (i) Many forces like stress/strength relationship and varying environmental conditions can act upon the item and produce failure.
- (ii) It signifies "approach to a stable state" which

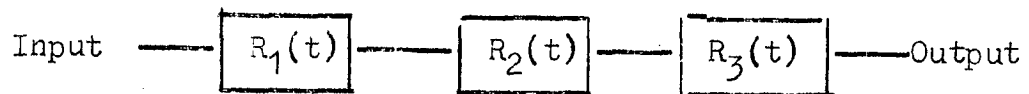
results from the mixing of part ages when failed elements in the system are replaced or repaired. Over a period of time, the system hazard rate oscillates, but this cyclic movement diminishes in time and approaches a stable state with a constant hazard rate.

- (iii) Exponential distribution function approximates some other function over a particular interval of time for which the true hazard rate is essentially constant.

### 2.3 RELIABILITY CONFIGURATIONS

A method is needed to reflect the reliability connectivity of the many part types having different stress-determined failure rates that would normally make up a complex equipment.

In general, the serial equipment configuration is represented by the following block diagram:



Failure of any one part in the series would result in failure of the equipment. Further, it is assumed that failure of any part would occur independently of the operation of other components.

$$\text{Hence } R_s(t) = R_1(t) \cdot R_2(t) \dots R_i(t) \dots R_n(t)$$

where

$R_s(t)$  is the series reliability, and  $R_i(t)$  is the

reliability of the "ith" block for the time "t".

Introducing constant failure rate concept, the system reliability as a function of the reliability of parts and components becomes

$$R(t) = \prod_{i=1}^n e^{-\lambda_i t} = e^{-\lambda_1 t} \cdot e^{-\lambda_2 t} \dots e^{-\lambda_n t}$$

Simplifying,  $R(t) = e^{-(\lambda_1 + \lambda_2 + \dots + \lambda_n)t}$

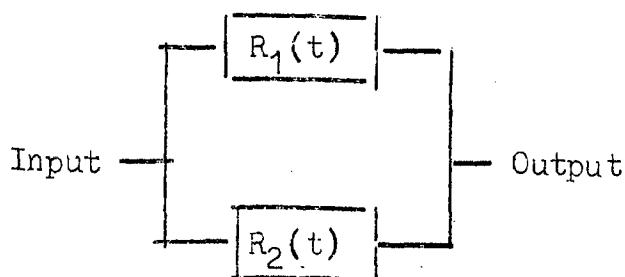
The general form of this expression becomes

$$R(t) = \exp \left[ -t \sum_{i=1}^n \lambda_i \right]$$

The failure-rate parameter is valid both for the conditions of component-part testing and for application in complete equipments, the failure rate for the equipment is the sum of the part failure rates.

$$\lambda(\text{equipment}) = \sum \lambda(\text{parts})$$

A parallel configuration shows that when a part fails there is an alternate part or item configuration designed to insure equipment success. A two element parallel reliability configuration is represented by the following block diagram:



The reliability of the parallel configuration can be represented by:

$$R_p = 1 - (1-R_1).(1-R_2)$$

For  $n$  blocks connected in a parallel reliability configuration, the reliability of the configuration can be expressed by :

$$R_p(t) = 1 - (1-R_1).(1-R_2) \dots (1-R_n)$$

The series and parallel reliability configuration (and combinations of these) represent the basic concepts involved in estimating the reliability of complex equipment.

#### 2.4 PART FAILURE MODELING

The basic concept which underlies reliability evaluation is that system failure is a reflection of part failure. A method for estimating part failure rates is thus needed. The most direct approach to estimating part failure rates involves the use of large scale data collection efforts to obtain the relationships (i.e., models) between engineering and reliability variables. This approach utilizes controlled test data to:

- (a) derive relationships between design and generic reliability factors, and
- (b) develop factors for adjusting the reliability to estimate field reliability when considering application conditions.

These data have been included in MIL-HDBK-217D in a form suitable for estimating stress-related failure rates.

Part failure models vary with different part types, however, their general form is:

$$\lambda_{\text{part}} = (\lambda_b) (\pi_E) (\pi_A) (\pi_Q) \dots (\pi_n)$$

where

$\lambda_{\text{part}}$  is the total part failure rate,

$\lambda_b$  is the base failure rate,

$\pi_E$  is the environmental adjustment factor,

$\pi_A$  is the application adjustment factor,

$\pi_Q$  is the quality adjustment factor,

$\pi_n$  is the symbol for a number of additional adjustment factors which account for cycling effect, construction class and other factors that modify failure rate.

Base failure rates, in general, have been established from tests conducted under accelerated stress conditions which speed up the aging process. Field data collection and analysis efforts have indicated part failure rates well above those determined from laboratory testing. To account for the adverse influence of the application environment and to align the base failure rate ( $\lambda_b$ ) with experience, a series of factors, have been developed to account for specific production operation and maintenance and application environment stress factors. MIL-HDBK-217D completely describes failure rate models, failure rate data and



adjustment factors to be used in estimating the failure rate for the individual part types.

1. COMPOSITION RESISTORS
2. FILM RESISTORS
3. POWER FILM RESISTORS
4. WIREWOUND ACCURATE RESISTORS
$\lambda_p = (\lambda_b) \cdot (\pi_E) \cdot (\pi_R) \cdot (\pi_Q)$
5. RESISTOR NETWORK
$\lambda_p = 0.00066 (N_R) \cdot (\pi_T) \cdot (\pi_E) \cdot (\pi_Q)$
6. VARIABLE WIREWOUND RESISTORS
7. WIREWOUND SEMIPRECISION RESISTORS
8. VARIABLE COMPOSITION RESISTORS
9. VARIABLE FILM & PRECISION RESISTORS
$\lambda_p = (\lambda_b) \cdot (\pi_{TAPS}) \cdot (\pi_E) \cdot (\pi_R) \cdot (\pi_Q) \cdot (\pi_V)$
10. WIREWOUND PRECISION RESISTORS
11. WIREWOUND POWER RESISTORS
12. VARIABLE NONWIREWOUND RESISTORS
$\lambda_p = (\lambda_b) \cdot (\pi_{TAPS}) \cdot (\pi_R) \cdot (\pi_V) \cdot (\pi_Q) \cdot (\pi_E)$

TABLE 2.1(a)

1. Si/Ge (NPN/PNP) TRANSISTORS
$\lambda_p = (\lambda_b)(\pi_E)(\pi_A)(\pi_Q)(\pi_{S2})(\pi_C)(\pi_R)$
2. SILICON/GALIUM FIELD EFFECT TRANSISTORS
$\lambda_p = (\lambda_b)(\pi_E)(\pi_A)(\pi_Q)(\pi_C)$
3. UNIUNCTION TRANSISTORS
$\lambda_p = (\lambda_b)(\pi_E)(\pi_Q)$

TABLE 2.1(b)

1. PAPER & PLASTIC FILM CAPACITORS
2. MICA CAPACITORS
4. CERAMIC CAPACITORS
5. ALUMINIUM ELECTROLYTIC CAPACITORS
$\lambda_p = (\lambda_b)(\pi_E)(\pi_Q)(\pi_{CV})$
6. TANTALUM ELECTROLYTIC CAPACITORS
$\lambda_p = (\lambda_b)(\pi_E)(\pi_{SR})(\pi_Q)(\pi_{CV})$
7. VARIABLE CERAMIC CAPACITORS
8. VARIABLE PISTON TYPE CAPACITORS
9. VARIABLE AIR TRIMMER CAPACITORS
$\lambda_p = (\lambda_b)(\pi_E)(\pi_Q)$
10. VACUUM OR GAS CAPACITORS
$\lambda_p = (\lambda_b)(\pi_E)(\pi_Q)(\pi_{CF})$

TABLE 2.1(c)

## 1. GENERAL PURPOSE (Si/Ge) DIODES

$$\lambda_p = (\lambda_b)(\pi_E)(\pi_Q)(\pi_R)(\pi_A)(\pi_{S2})(\pi_C)$$

## 2. AVALANCHE &amp; ZENER DIODES

$$\lambda_p = (\lambda_b)(\pi_E)(\pi_A)(\pi_Q)$$

## 3. THYRISTORS

$$\lambda_p = (\lambda_b)(\pi_Q)(\pi_E)(\pi_R)$$

TABLE 2.1 (d)

The TABLES 2.1(a), 2.1(b), 2.1(c), 2.1(d) show the part failure rate models of different types of Resistors, Transistors, Capacitors and Diodes respectively where  $\lambda_p$  is in failures/ $10^6$  hours.

The details of different factors in the part failure rate models are described in CHAPTER-III.

# chapter 3

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CHAPTER - III

RELIABILITY COMPUTATION METHODS

3.1 PARTS COUNT METHOD

This prediction method is useful in bid (proposal) stage when the design of an electronic circuit has not advanced to the goal where detailed component lists and part stresses are known. The Parts Count Method requires less information. The quantity of different component types, quality level of the components and the application environment are dealt with in this method. The general expression for circuit failure rate with this method is given below:

$$\lambda(\text{circuit}) = \sum_{i=1}^n N_i (\lambda_G \pi_Q)_i \dots \quad (3.1)$$

for a given environment

where

$\lambda(\text{circuit})$  = total circuit failure rate (failures/ $10^6$ hr.)

$\lambda_G$  = generic failure rate for the  $i$ th generic component (failures/ $10^6$ hr.)

$\pi_Q$  = quality factor for the  $i$ th generic component

$N_i$  = quantity of  $i$ th generic component

$n$  = number of different generic component categories

When the several units of a circuit or equipment are operated in different environmental conditions, the different environment-affected failure rates are calculated and then added to determine the total circuit or equipment failure rate. The quality factors used with electronic components are not necessarily the same values used in section 3.2, i.e., Part Stress Analysis.

### 3.2 PART STRESS ANALYSIS METHOD

Greatest amount of detail is needed in this method. The Part Stress Analysis method is appropriate when the electronic circuit design has advanced to a goal where detailed component lists are available and the stresses encountered by the components in the circuit are calculated. The general expression for circuit failure rate has been mentioned in the previous chapter (Chapter-II, section 2.4). Factors influencing part failure rates for different part categories are described in the following sub-sections [26].

#### 3.2.1 Base Failure Rate

MIL-HDBK-217D gives base failure rates,  $\lambda_b$ , to the various part categories.

The general model used to quantify the term  $\lambda_b$  for specific types or classes of resistors is as follows:

$$\lambda_b = A e^{B \left( \frac{T+273}{N_T} \right)^G} \left[ \left( \frac{S}{N_S} \right) \left( \frac{T+273}{273} \right) \right]^H$$

where

- A is an adjustment factor for each type of resistor to adjust the model to the appropriate failure rate level.
- e is the natural logarithm base, 2.718
- T is the ambient operating temperature ( $^{\circ}\text{C}$ )
- $N_T$  is a temperature constant
- B is a shaping parameter
- G, H, J are acceleration constants
- $N_S$  is a stress constant
- S is the electrical stress and is the ratio of operating power to rated power.

The general model for capacitor base failure rates ( $\lambda_b$ ) is as follows:

$$\lambda_b = A \left[ \left( \frac{S}{N_S} \right)^H + 1 \right] \cdot e^{B \left( \frac{T+273}{N_T} \right)^G}$$

where,

- A is an adjustment factor for each different type of capacitor, to adjust the model to the proper failure rate.
- S represents the ratio of operating to rated voltage
- $N_S$  is the stress constant
- e is the natural logarithm, 2.718
- T is the operating ambient temperature ( $^{\circ}\text{C}$ )

$N_T$  is a temperature constant

B is a shaping parameter

G and H are acceleration constants

The equation for the base failure rate ( $\lambda_b$ ) for semiconductor diodes and transistors is as follows:

$$\lambda_b = Ae^x$$

where

$$x \text{ is } \left[ \frac{N_T}{273+T+(\Delta T)S} \right] + \left[ \frac{273+T+(\Delta T)S}{T_M} \right]^P$$

A is a failure rate scaling factor

e is the natural logarithm base, 2.718

$N_T$ ,  $T_M$  and P are shaping parameters

T is the operating temperature ( $^{\circ}\text{C}$ )

T is the difference between typical maximum allowable temperature with no junction current or power and the typical maximum allowable temperature with full rated junction current or power.

S is the stress ratio of operating electrical stress to rated electrical stress.

For calculating S the necessary informations are listed below:

(1) For Transistors

(a) Single device in use

$$S = \frac{P_{OP}}{P_{MAX}} \text{ for Germanium}$$



$$\text{and } S = \frac{P_{OP}}{P_{MAX}} \quad (\text{C.F.})$$

where

$P_{OP}$  = actual power dissipated

$P_{MAX}$  = maximum rated power at  $T_S$

(b) Dual device in single case (equally rated).

$$S = \left[ \frac{P_1}{P_S} + P_2 \left( \frac{2P_S - P_T}{P_T \times P_S} \right) \right] \quad (\text{C.F.})$$

where

$S$  = stress ratio of side being evaluated

$P_1$  = power dissipation in side being evaluated

$P_2$  = power dissipation in the other side of device

$P_S$  = maximum power rating at  $T_S$  on one side with other side not operating

$P_T$  = maximum/ <sup>power</sup> rating at  $T_S$  with both sides operating

(2) For General Purpose Diodes and Thyristors

$$S = \frac{I_{OP}}{I_{MAX}} \quad \text{for Germanium}$$

$$= \frac{I_{OP}}{I_{MAX}} \quad (\text{C.F.})$$

where

$I_{OP}$  = operating average forward current

$I_{MAX}$  = maximum rated average forward current at  $T_S$

## (3) For Zener Diodes

$$S = \frac{P_{OP}}{P_{MAX}} \cdot (C.F) \quad \text{or} \quad S = \frac{I_{Z(OP)}}{I_{Z(MAX)}} \cdot (C.F)$$

where

$P_{OP}$  = actual power dissipated

$P_{MAX}$  = maximum rated power at  $T_S$

$I_{Z(OP)}$  = actual operating Zener current

$I_{Z(MAX)}$  = maximum rated Zener current at  $T_S$

C.F. = stress correction factor

If  $T_S = 25^\circ\text{C}$  and  $175^\circ\text{C} \leq T_{MAX} < 200^\circ\text{C}$

C.F. = 1

If  $T_S > 25^\circ\text{C}$  and  $175^\circ\text{C} \leq T_{MAX} < 200^\circ\text{C}$

$$C.F. = \frac{175 - T_S}{150}$$

If  $T_S = 25^\circ\text{C}$  and  $T_{MAX} < 175^\circ\text{C}$

$$C.F. = \frac{T_{MAX} - 25}{150} \quad \text{and} \quad T = T_A \text{ (or } T_C) + (175 - T_{MAX})$$

If  $T_S > 25^\circ\text{C}$  and  $T_{MAX} < 175^\circ\text{C}$

$$C.F. = \frac{T_{MAX} - T_S}{150}$$

$$\text{and } T = T_A \text{ (or } T_C) + (175 - T_{MAX})$$

where

$T_A$  is ambient temperature ( $^\circ\text{C}$ )

$T_C$  is case temperature ( $^\circ\text{C}$ )

The higher the temperature at which an electronic part operates, the shorter its lifetime. Accordingly, the failure rate will be higher for higher temperatures of operation. The use of electronic components below their rated voltage or power increases their reliability.

The base failure rates as functions of temperature and electrical stress are tabulated in MIL-HDBK-217D for different part type. These tables are used to calculate the base failure rates of different components in the actual electronic circuit.

### 3.2.2. Part Quality

The quality of a part is taken into account in part failure rate model and is designated by  $\pi_Q$ . If a particular part is purchased to a multilevel quality specification (established reliability, ER), the appropriate value for  $\pi_Q$  is selected. Parts which are not covered by multilevel quality specifications (non-ER), have two quality levels designated as "MIL-SPEC" and "LOWER". If the part is used in complete accordance with the applicable specification,  $\pi_Q$  value for "MIL-SPEC" should be used. If the requirements are waived,  $\pi_Q$  value for "LOWER" should be used. The different parts with their multi-level quality specifications are listed in Table 3.1.

PART	QUALITY DESIGNATORS
1. Transistors	JANTXV, JANTX, JAN
2. Diodes	JANTXV, JANTX, JAN
3. Capacitors, Established Reliability (ER)	L, M, P, R, S
4. Resistors, Established Reliability (ER)	M, P, R, S

Table 3.1 Parts with Multi - level Quality Specifications.

If the diodes and transistors are sealed or encapsulated with organic materials, another quality designator "PLASTIC" can be used.

### 3.2.3 Environment

The factor  $\pi_E$  is used to consider the effects of various environmental stresses excepting ionizational potential in all part failure rate models and value of this factor is described by MIL-HDBK for the specific part types. These environments cover the major areas of component use and a brief description of these environments are shown in Table 3.2 [ 26, 32, 34, 35].

Environment	$\pi_E$ Symbol	Description
Ground, Benign	$G_B$	Optimum engineering operation and maintenance for laboratory environment.
Ground, Fixed	$G_F$	Less severe than ideal for installation in unheated buildings.
Ground, Mobile	$G_M$	Conditions more severe than $G_F$ mostly for vibration and shock.
Space, Flight	$S_F$	Approaches $G_M$ without access for maintenance.
Manpack	$M_P$	Portable electronic equipment being manually transported while in operation.
Naval, Sheltered	$N_S$	Conditions similar to $G_F$ subject to occasional high shock and vibration.
Naval, Unsheltered	$N_U$	Similar to $N_S$ subject to repetitive high levels of shock and vibration.
Naval, Undersea, Unsheltered	$N_{UU}$	Equipment immersed in salt water.
Naval, Submarine	$N_{SB}$	Equipment installed in submarines
Naval, Hydrofoil	$N_H$	Equipment installed in hydrofoil vessel.
Airborne, Inhabited, Transport	$A_{IT}$	Conditions without environmental extremes of pressure, temperature, shock and vibration in aircraft transports or bombers.
Airborne, Inhabited, Fighter	$A_{IF}$	Same as $A_{IT}$ but installed on aircraft fighters.

Airborne, Uninhabited, Transport	$A_{UT}$	Extreme pressure, vibration and temperature cycling may be intensified by contamination from oil, hydraulic fluid and engine exhaust.
Airborne, Uninhabited, Fighter	$A_{UF}$	Same as $A_{UT}$ but installed on aircraft fighters.
Airborne, Rotary, Winged	$A_{RW}$	Equipment installed on helicopters.
Missile, Launch	$M_L$	Severe conditions of noise, vibration and other environments related to missile launch.
Cannon, Launch	$C_L$	Same as $M_L$ related to cannon launching to target impact.
Undersea, Launch	$U_{SL}$	Undersea torpedo mission and missile launch.
Missile, Free Flight	$M_{FF}$	Missiles in non-powered free flight.
Airbreathing Missile Flight	$M_{FA}$	Powered flight of air breathing missile.

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Table 3.2 Environmental Symbol Identification and Description. (Source: MIL-HDBK-217D).

#### 3.2.4 Other $\pi$ Factors

The  $\pi$  factors excepting  $\pi_E$  and  $\pi_Q$  applied to specific part failure rate models are defined in MIL-HDBK-217D for each part. Table 3.3 presents an overall listing of  $\pi$  factors used in failure rate models as applicable to resistors, capacitors, transistors and diodes.

$\pi$ Factor	Description
Resistors	
$\pi_R$	Resistance Factor Effect of resistor ohmic values.
$\pi_T$	Temperature Factor- Effect of temperature for resistor network
$\pi_C$	Construction class factor-Influence of construction class of various resistors.
$\pi_V$	Voltage Factor - Effect of applied voltage in variable resistors in addition to wattage included within $\lambda_b$ .
$\pi_{TAPS}$	Effect of multiple taps on variable resistors.
Capacitors	
$\pi_{SR}$	Series Resistance Factor - Effect of series resistance in circuit application of some electrolytic capacitors.
$\pi_{CV}$	Capacitance Factor - Effect of capacitance value.
$\pi_{CF}$	Configuration Factor - Effect of fixed and variable constructions on vacuum or Gas capacitors.

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Transistors and Diodes

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$\pi_A$	Application Factor - Effect of application in terms of circuit function
$\pi_R$	Rating Factor - Effect of maximum power or current rating
$\pi_C$	Complexity Factor-Effect of multiple devices in a single package.
$\pi_{S2}$	Voltage Stress Factor - Effect of second electrical stress (application voltage) in addition to voltage included in $\lambda_b$ .

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Table 3.3  $\pi$  Factors (except  $\pi_E$  and  $\pi_Q$ ) for Resistors, Capacitors, Transistors and Diodes.



# chapter 4

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CHAPTER - IVCIRCUIT RELIABILITY EVALUATION

## 4.1 INTRODUCTION

Calculation of failure rate for an electronic assembly, unit or system requires knowledge of the failure rate of each part of which the item is comprised. If we assume that the item will fail when any of its parts fail, the failure rate of the item will equal to the sum of the failure rate of its parts. This can be expressed as:

$$\lambda = \sum_{i=1}^n \lambda_i$$

where,

$\lambda_i$  = failure rate of the  $i$ th parts,

$n$  = number of parts

Generally, two methods discussed in the previous chapters (Chapter - III) are used to make reliability estimates. The Parts Count method is normally used at a preliminary stage of design and is the least accurate of the two methods. Failure rates from Parts Count are stress independent except for the environmental condition.

The Parts Stress Analysis is more cumbersome with many factors and is applicable during the later design phases where actual hardware and circuits are being

designed. It should be noted, however, that the parts stress analysis method may also be used during any phase provided that enough detailed information is available.

The obtainable accuracy in system failure rate prediction can be achieved by the designer if a tool more powerful than Parts Count and faster to use than Parts stress Analysis. This involves database programming which is best suited for homogeneous data. All component data are stored and all tables are handled by the system.

The only factor needed from circuit analysis is the component loading. When load on each component is specified, the contents of the failure rate table is multiplied by the component factors from the component database.

#### 4.2 CREATING DATABASE FILES USING dBASE III PLUS

In the previous chapter (Chapter - III), we have seen that base failure rate,  $\lambda_b$ , is dependent on operating temperature and loading (electrical stress) of each component. The base failure rate values for each component part corresponding to different temperatures (starting from zero) and loadings (starting from 0.1 to 1.0 with a gap of 0.1) are recorded in MIL-HDBK-217D. These values are recorded at each  $5^{\circ}\text{C}$  interval or  $10^{\circ}\text{C}$  interval.  $\lambda_b$  value corresponding to a particular loading at any temperature in this interval is very close the value recorded at the immediate next temperature value with the same

loading. Same is the case where temperature is fixed and loading value lies in between the loading interval written in MIL-HDBK-217D.

Database files using dBASE II PLUS are created first and the values of  $\lambda_b$  are stored in these files. These files look like the tables of base failure rate,  $\lambda_b$ , of different components where first record, corresponds to  $0^\circ\text{C}$  temperature and the fields correspond to 0.1, 0.2, 0.3, 0.4, 0.5, 0.6, 0.7, 0.8, 0.9, 1.0 loadings respectively. The second record corresponds to  $5^\circ\text{C}$  temperature and so on. For resistors, these tables are TRES1, TRES2, TRES3, ...etc. For capacitors, these tables are CAP1, CAP2, CAP3, ...etc. For diodes, these are DIOD1, DIOD2, DIOD3, ... etc. For transistors, these tables are TRAN1, TRAN2, TRAN3, ...etc.

Besides these database files, one file named MODE is also created where a particular record corresponds to a particular component type and the different fields denote the different environments i.e.  $G_B$ ,  $S_F$ ,  $G_F$ , ... etc. Environmental mode factor,  $E$ , can be found out corresponding to a particular component type and specified environment. The details of these databases are described in Appendix - A and listed in Appendix - B.

#### 4.3 CALCULATION OF LOADING (ELECTRICAL STRESS)

For the computer aided analysis of an electronic circuit, the circuit is represented in terms of circuit

equations with the help of suitable device models. Therefore, a large set of algebraic differential equations has to be solved for the analysis of large electronic circuits. Such non-linear equation can be solved with the help of Newton's method based algorithms. But Newton's method gives overflow or slow convergence problem as higher order derivatives are neglected in this method. Hence, Newton's method is modified to overcome this problem. The software packages [20, 21] have been implemented for d.c. and transient analysis of the practical electronic circuits.

#### 4.3.1 Transient Analysis:

The transient analysis denotes the time domain response of the circuit. The circuit equations are solved at successive time points, beginning with initial conditions computed in d.c. analysis. The circuit equations which express the transient behaviour of a circuit can be written by a set of algebraic and differential equations of the form:

$$G(W, q, \dot{q}, t) = 0 \quad \dots(4.1)$$

The vector function  $G$  comprises Kirchhoff's voltage and current law equations and the branch constitutive equations. The vectors  $W(t)$  and  $q(t)$  are computed by solving (4.1) for all the values of time in the interval  $t_0 \leq t \leq t_{\max}$ . The step-wise procedure for transient analysis is described as:

- Step 1 : Given the initial time  $t_0$  and initial conditions, determine  $W(t_0)$ ,  $q(t_0)$  by d.c. solution, choose an initial step size  $h_1$  and set  $i = 1$ .
- Step 2 : Set  $t_i = t_{i-1} + h_i$
- Step 3 : Discretize  $\dot{q}(t_i)$
- Step 4 : Values of  $W(t_i)$  and  $q(t_i)$  are predicted from their previous corresponding values using modified Newton's method. These predicted values are used as initial estimate for the solution of nonlinear equations in step 5.
- Step 5 : Estimate the truncation error in the discretization. If the convergence criteria is not met within specified maximum iterations then set  $h_i = h_i/2$  and go to step 2. Otherwise, compute new time step  $h_{i+1}$  such that  $h_{i+1}$  is maximum step size with the allowable truncation error.
- Step 6 : If  $t_i < t_{\max}$ , then set  $i = i+1$  and go to step 2. Otherwise, the transient analysis is complete.

#### 4.3.2 D.C. Analysis:

In d.c. analysis, the non-linear equations representing the circuit behaviour are linearized around an initial estimate. The ideal capacitors and inductors are

replaced by open and short circuit respectively and the source value remains fixed in d.c. analysis. The d.c. analysis of a circuit representing equation (4.1) gives the values  $W$  and  $q$  for which  $\dot{q} = 0$ . Now, equation (4.1) becomes:

$$G(W, q, 0, t_0) = 0 \quad \dots(4.2)$$

The stepwise procedure for d.c. analysis is as follows:

- Step 1 : Read circuit data and select suitable values for unknown nodal voltages.
- Step 2 : Determine the minimal spanning tree.
- Step 3 ; Formulate the linearized circuit equations by including contribution of each element of the circuit in the admittance matrix  $G$  and current vector  $B$ .
- Step 4 : Solve linearized circuit equations formulated in step 3 to calculate Newton's correction vector in nodal voltages.
- Step 5 : Obtain the new values of unknown node voltages by adding algebraically, Newton's correction vector to the corresponding nodal voltages.
- Step 6 : Compute the branch voltages from node voltages. Modify the junction voltages of the diodes and transistors (foreward biased) appropriately.

Step 7 : Determine the nodal voltages from branch voltages using the minimal spanning tree and node to datum path matrix.

Step 8 : If the circuit equations are satisfied with specified tolerances, stop; otherwise go to step 3.

The software packages [20, 21] for circuit analysis (d.c. and transient behaviour) has been utilized and modified to get the loadings of each component in the circuit. The loadings are either the voltage ratios (operating/rated) or the power ratios (operating/rated).

#### 4.4 COMBINATION OF LOADING AND OTHER FACTORS IN dBASE PROGRAMMING

For each component specification, the analytical model for the part failure rate,  $\lambda_p$ , has been used. For the calculation of part failure rate of each component in the circuit, a program is written using dBASE III PLUS programming language. The loading of each component along with other factors (temperature, environment, part specification, quality level etc.) are given as inputs to this program. Finally, the failure rate of each component has been calculated and recorded in a database file. At the end of this output file, total part failure rate is also recorded.



The program developed is a menu-driven system where options can be simply selected to calculate the part failure rate of a particular component in the circuit. The details of this software package is described in Appendix-A.

chapter 5

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## CHAPTER - V

### COMPUTATIONS AND RESULTS

#### 5.1 COMPUTATIONS

Before component parts can be properly selected for a specific circuit, the performance requirements and environmental conditions under which the circuit is to operate must first be determined. The final choice is based on electrical circuit conditions and upon the physical dimensions.

A prime source of data on electronic component parts, and their ability to perform under various environmental conditions, is the military specification which applies to the particular component parts.

A bipolar ECL Schmitt Trigger circuit, comprising of five resistors and two transistors, shown in Fig. 5.1(a) is considered for reliability evaluation. The input is set for a trapezoidal function of time as shown in Fig. 5.1(b). The detailed information about the specifications and dimensions of the constituent component parts are listed in Table 5.1.

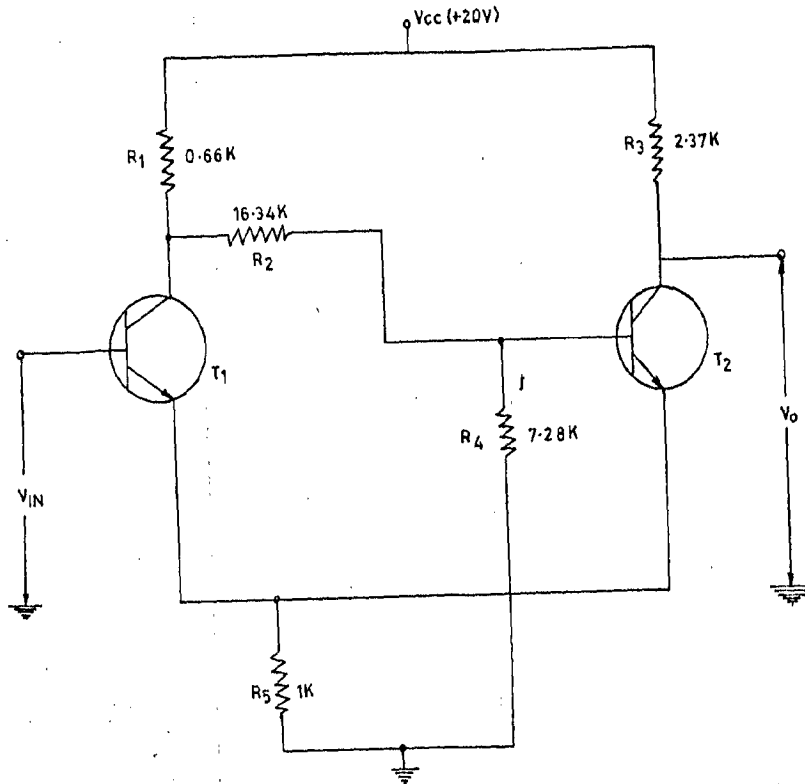
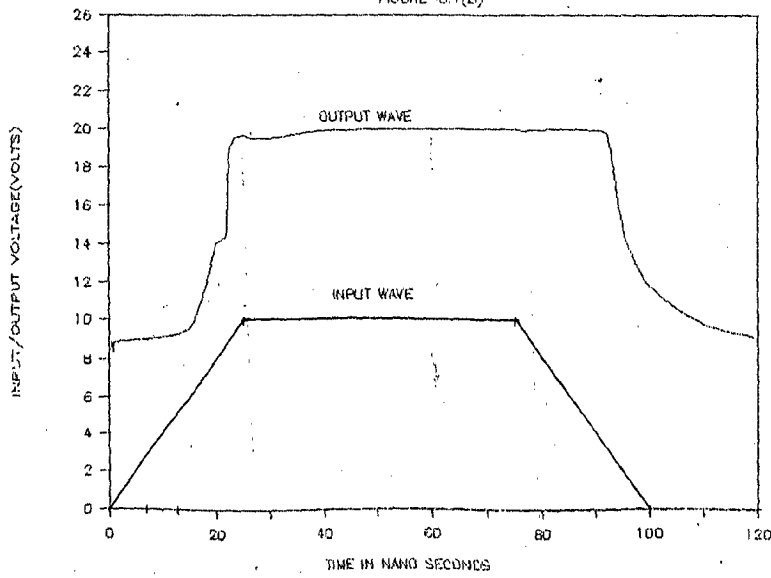


FIG. 5-1(a) - ECL SCHMITT TRIGGER CIRCUIT

I/O CHARACTERISTICS OF SCHMITT TRIGGER

FIGURE-5.1(B)



The operating temperature is  $30^{\circ}\text{C}$ . The environment is Ground, Mobile and its symbol is  $G_M$ . The values of the resistances (in kilo-ohms) are defined in the Fig. 5.1(a).

From the analysis of the circuit it is found that electrical stress ratios of different components are 0.566, 0.245, 0.327, 0.345, 0.221, 0.001 and 0.127 respectively. Moreover  $V_{CE}/V_{CEO}$  of the two transistors are found to be 0.10 and 0.40 approximately. The total failure rate of the circuit applying "Parts Count" and "Part-stress Analysis" methods are computed in the following way.

#### (1) Parts Count Method

The general expression for circuit failure rate as described in chapter-III can be defined as follows:

$$\lambda_{\text{Circuit}} = \sum_{i=1}^n N_i (\lambda_G \pi_Q)_i \text{ f./}10^6 \text{ hr.} \dots (5.1)$$

From MIL-HDBK-217D (Tables 5.2-10, 5.2-11, 5.2-12, 5.2-14), generic failure rate ( $\lambda_G$ ) and quality factor ( $\pi_Q$ ) can be found.

No. of fixed, wirewound resistors = 3

$$\lambda_G = 0.095 \quad \text{and} \quad \pi_Q = 1.0$$

No. of fixed, film resistor = 1

$$\lambda_G = 0.012, \quad \pi_Q = 1.0$$

No. of fixed, power film resistor = 1

$$\lambda_G = 0.12, \quad \pi_Q = 1.0$$

No. of Silicon, NPN transistor = 2

$$\lambda_G = 0.062, \quad \pi_Q = 1.0$$

The values of  $\lambda_G$  and  $\pi_Q$  are valid for environment 'G<sub>M</sub>' and quality level 'M' for resistors and 'JAN' for transistors.

Now, equation 5.1 becomes

$$\begin{aligned} \lambda_{\text{CIRCUIT}} &= 3 \times 0.095 \times 1.0 + 1 \times 0.012 \times 1.0 + 1 \times 0.12 \times 1.0 + 2 \times 0.062 \times 1.0 \\ &= 0.285 + 0.012 + 0.12 + 0.124 \\ &= 0.541 \end{aligned}$$

Hence, in Parts count method the total failure rate of the Schmitt trigger circuit is 0.541 failures/10<sup>6</sup> hour.

#### (B) Part-stress Analysis Method

The general part failure rate model for fixed resistors described in Chapter-III is as follows:

$$\lambda_p = \lambda_b (\pi_E \times \pi_R \times \pi_Q) \text{ failures}/10^6 \text{ hour} \dots (5.2)$$

where the general model to quantify  $\lambda_b$  is as follows:

$$\lambda_b = A e^{B \left( \frac{T+273}{N_T} \right)^G} \left[ \left( \frac{S}{N_S} \right) \left( \frac{T+273}{273} \right)^J \right]^H \dots (5.3)$$

The general part failure rate model for transistors described in Chapter-III is as follows:

Table 5.1 SPECIFICATION &amp; DIMENSION OF COMPONENT PARTS

COM PON ENT	COMPONENT TYPE	POWER RATING (watts)	QUALITY LEVEL	SPEC.	STYLE	APPLIC -ATION	COMPLE -XITY
R1	Fixed,Wirewound	1.000	M	MIL-R- 39005	RBR		
R2	Fixed,Film	0.050	M	MIL-R- 55182	RNR		
R3	Fixed,Wirewound	0.100	M	MIL-R- 39005	RBR		
R4	Fixed,Power Film	0.125	MIL-SPEC	MIL-R- 11804	RD		
R5	Fixed,Wirewound	0.125	M	MIL-R- 39005	RBR		
T1	Silicon,NPN	0.150	JAN	MIL-S- 19500		LINEAR	SINGLE TRANSI STOR
T2	Silicon,NPN	0.150	JAN	MIL-S- 19500		LINEAR	SINGLE TRANSI STOR

Table 5.2 FAILURE RATE OF SCHMITT TRIGGER CIRCUIT

COM PON ENT	STRESS	BASE RATE (LAMDA) f./10 <sup>6</sup> hr.	PIE	PIR	PIQ	PIA	PIC	PIS2	PART RATE (LAMDA) f./10 <sup>6</sup> hr.
R	0.566	0.00500	9.80	1.00	1.00	0.00	0.00	0.000	0.049000
R	0.245	0.00100	7.80	1.00	1.00	0.00	0.00	0.000	0.007800
R	0.327	0.00440	9.80	1.00	1.00	0.00	0.00	0.000	0.043120
R	0.345	0.01200	8.80	1.00	1.00	0.00	0.00	0.000	0.105600
R	0.221	0.00400	9.80	1.00	1.00	0.00	0.00	0.000	0.039200
T	0.001	0.00070	18.00	1.00	1.20	1.50	1.00	0.300	0.006804
T	0.127	0.00084	18.00	1.00	1.20	1.50	1.00	0.477	0.012970

\*\*\* Total \*\*\*

0.264494

TABLE 5.1(A) CALCULATION OF FAILURE RATE

WPO- $\pi$ ENT	$\pi$ E	$\pi$ Q	$\pi$ R	$\pi$ C	$\pi$ S <sub>2</sub>	P	A	B	$N_T$	G	$N_S$	H	J	$T$ (°C) $\Delta T$	$T_M$	S	$\lambda_b$	$\lambda_p$
$R_1$	9.8	1.0	1	-	-	-	$3.1(10)^{-3}$	1	398	10	1	1.5	1	30	-	0.566	0.00545	0.05341
$R_2$	9.8	1.0	1	-	-	-	$5.0(10)^{-5}$	3.5	398	1	1	1	1	30	-	0.245	0.00094	0.00733
$R_3$	9.8	1.0	1	-	-	-	$3.1(10)^{-3}$	1	398	10	1	1.5	1	30	-	0.327	0.00412	0.040376
$R_4$	8.8	1.0	1	-	-	-	$7.33(10)^{-3}$	0.202	298	2.6	1.45	1.3	0.89	30	-	0.345	0.01072	0.094336
$R_5$	9.8	1.0	1	-	-	-	$3.1(10)^{-3}$	1	398	10	1	1.5	1	30	-	0.221	0.00374	0.036652
$T_1$	18.0	1.2	1	1	0.3	10.5	0.0189	-	-1052	-	-	-	-	30	150	448	0.0005978	0.0058
$T_2$	18.0	1.2	1	1	0.4766	10.5	0.0189	-	-1052	-	-	-	-	30	150	448	0.000743	0.01147
Total																	0.249384	

$\lambda_b$  and  $\lambda_p$  are the number of failures/10<sup>6</sup> hour.



$$\lambda_p = \lambda_b (\pi_E \times \pi_A \times \pi_Q \times \pi_R \times \pi_{S2} \times \pi_C) \text{ failures}/10^6 \text{ hr.} \quad \dots(5.4)$$

where  $\lambda_b = A e^x \quad \dots(5.5)$

and  $x = \left( \frac{N_T}{273+T+(\Delta T)S} \right) + \left( \frac{273+T+(\Delta T)S}{T_M} \right)^P \quad \dots(5.6)$

The total failure rate is given in Table 5.1(A).

## 5.2 RESULTS

The tables of  $\lambda_b$  (for different temperatures Vs. electrical stress ratios) are in the form that temperatures are described at a regular gap of 5 or 10°C and the stress has 10 columns starting from 0.1 with a gap of 0.1. These tables have been utilized here to calculate the part failure rates in such a way that for any intermediate values of temperature or stress, immediate next values of  $\lambda_b$  has been taken into account. This may cause a slight deviation from the values of  $\lambda_b$  computed earlier. But this deviation is too small to consider for total circuit failure rate calculation. Moreover, the data base structure is utilized here for calculating  $\lambda_b$ . The results in the report form is tabulated in Table 5.2.

# chapter 6

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## CHAPTER - VI

### CONCLUSIONS

Reliability is a consideration at all levels of electronics from materials to operating systems because components are made up of materials; these components are used in a circuit of increasing complexity. Therefore, at any level of development and design of electronic circuits, it is necessary to find the reliability of the circuit. An attempt has been made in this dissertation to evaluate the electronic circuits, with the failure rate data obtained from field use of past system, using the database structures for the various data records.

Two main limitations of reliability evaluation are the ability to accumulate data of known validity for future application and the complexity of reliability evaluation technique. Data useful to design of electronic circuits for the selection, specification and use of components is highly scattered. But a thorough study and knowledge of the military component part specifications is the first and probably the most useful source. Out of the two techniques for evaluating electronic circuits described in Chapter - III, the second one, Part stress analysis technique, which required greatest amount of detail and is applicable during the later design phase, is adopted in this dissertation to calculate the failure rate of any electronic circuit. As an example,

Schmitt Trigger circuit [ fig. 5.1(a) ] is taken for its reliability evaluation. The database structures for base failure rates of different types of components are made. These structures are handled in the program written to calculate the part failure rate of the components. The different types of models of part failure rate are described in Chapter - II.

The use of database structures and menu-driven program show that for evaluating any component part in the circuit one has to select the type of the component first and then the other factors responsible for part failure of the associated part are to be given accordingly. Final values of part failure rates are stored in a database structure to have an idea of different application factors as well as the failure rates.

APPENDIX - ASOFTWARE PACKAGE USING DATABASE STRUCTURES

Figure A-1 shows the organization of the computer program for reliability evaluation of electronic circuits using database structures for the failure rate data. The brief description of various sub-programs are given below:

- RELCKT : This is the main program for reliability evaluation of electronic circuits (circuits consisting of capacitors, diodes, resistors and transistors). When this program is executed, it shows 4 options to the user. Options are the component types (capacitors, diodes, resistors and transistors).
- CAPREL : This sub-program calculates the failure rate of any capacitor. When executed independently or opted from main program (RELCKT), it shows 10 choices for 10 types of capacitors. If a particular capacitor type is selected, it calculates the failure rate using suitable part failure model of that type of capacitor (as shown in table 2.1(c)).
- DIODREL : This sub-program calculates the failure rate of any diode. When executed independently or opted from main program (RELCKT), it shows 3 choices for 3 types of diodes. If a particular diode type is selected, it calculates the failure rate using proper part failure model as described in table 2.1(d).

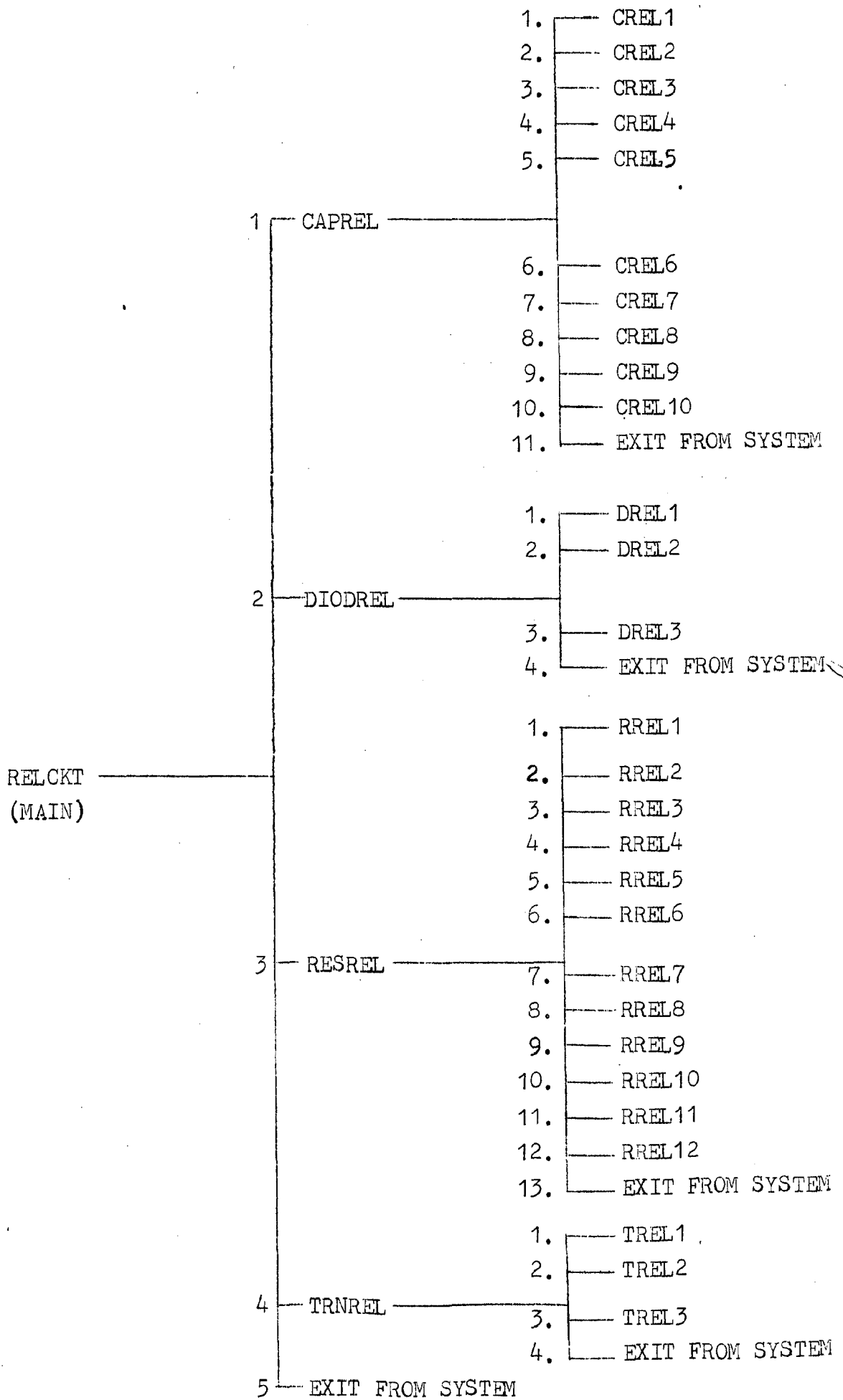


Fig. A-1 Organization of sub-programs for reliability evaluation of electronic circuits.

- RESREL : This sub-program calculates the failure rate of any resistor. When executed independently or opted from main program (RELCKT), it displays 12 choices for 12 types of resistors. If a particular resistor type is selected, it calculates the failure rate using the appropriate part failure model as described in table 2.1(a).
- TRNREL : This sub-program calculates the failure rate of any transistor. When executed independently or opted from main program (RELCKT), it displays 3 choices for 3 types of transistors. If a particular transistor type is selected, it calculates the failure rate using suitable part failure model as described in table 2.1(b).
- CREL1 : This sub-program, when executed independently or opted from CAPREL, calculates the failure rate of paper & plastic film capacitor. If  $T_{MAX} \leq 65^{\circ}C$ , it uses database file CAP1 and if  $65^{\circ}C \leq T_{MAX} \leq 85^{\circ}$ , file CAP2 is used. If  $85^{\circ}C < T_{MAX} \leq 125^{\circ}C$ , file CAP3 is used for base failure rate,  $\lambda_b$ . Record number 18 in the database structure MODE shows the  $\pi_E$  values for the different type of environments as discussed in Chapter III.
- CREL2 : This is for Mica capacitor. If  $T_{MAX} \leq 125^{\circ}C$ , database file CAP4 is used and if  $125^{\circ} < T_{MAX} \leq$

150°C, CAP5 is used for  $\lambda_b$ . Record no. 19 in MODE denotes the  $\pi_E$  values for different environments.

- CREL3 : For Glass Capacitor. If  $T_{MAX} \leq 125^\circ\text{C}$ , CAP6 and if  $125^\circ\text{C} < T_{MAX} \leq 150^\circ\text{C}$ , CAP7 is used for  $\lambda_b$  values. Record no. 20 in MODE shows the  $\pi_E$  values for different environments.
- CREL4 : For Ceramic capacitor. If  $T_{MAX} \leq 85^\circ\text{C}$ , file CAP8 and if  $85^\circ\text{C} < T_{MAX} \leq 125^\circ\text{C}$ , CAP9 is used for  $\lambda_b$  values. Record no. 21 in MODE shows the  $\pi_E$  values for different environments.
- CREL5 : For Tantalum Electrolytic capacitor. If  $T_{MAX} \leq 125^\circ\text{C}$ , file CAP10 is used for  $\lambda_b$ . Record no. 22 in MODE denotes the  $\pi_E$  values for different environments.
- CREL6 : For Aluminium Electrolytic capacitor. File CAP11 is used to find  $\lambda_b$ . Record no. 23 in MODE shows the  $\pi_E$  values for different environments.
- CREL7 : For Variable Ceramic capacitor. If  $T_{MAX} \leq 85^\circ\text{C}$ , database file CAP12 and if  $85^\circ\text{C} < T_{MAX} \leq 125^\circ\text{C}$ , file CAP13 is used to find  $\lambda_b$ . Record no. 24 in MODE defines the  $\pi_E$  values for different environments.



- CREL8 : For Variable Piston-type capacitor. If  $T_{MAX} \leq 125^{\circ}C$ , file CAP14 and if  $125^{\circ}C < T_{MAX} \leq 150^{\circ}C$ , file CAP15 is used to find  $\lambda_b$ . Record no. 25 in MODE shows the  $\pi_E$  values for different environments.
- CREL9 : For Variable Air Trimmer capacitor. File CAP16 is used to find  $\lambda_b$  and  $T_{MAX} \leq 85^{\circ}C$ . Record no. 26 in MODE shows the  $\pi_E$  values for different environments.
- CREL10 : For Vacuum or Gas capacitor. If  $T_{MAX} \leq 85^{\circ}C$ , file CAP 17 and if  $85^{\circ}C < T_{MAX} \leq 100^{\circ}C$ , file CAP18 is used to find  $\lambda_b$ . Record no. 27 in MODE defines the  $\pi_E$  values for different environments.
- DREL1 : This sub-program, when executed independently or opted from DIODREL, calculates the failure rate of General Purpose (Silicon or Germanium) diodes. If a silicon diode is selected, file DIOD1 and if a Germanium diode is selected, file DIOD2 is used to find  $\lambda_b$ . Record no. 16 in MODE denotes the  $\pi_E$  values for different environment.
- DREL2 : This is for Avalanche and Zener diode. File DIOD3 is used to find  $\lambda_b$ . Record no. 17 in MODE defines the  $\pi_E$  values for different environments.

- DREL3 : This sub-program is for Thyristors. Database structure DIOD<sup>4</sup> is used to find  $\lambda_b$ . The record no. 17 in MODE defines the  $\pi_E$  values for different environments in this case also.
- RREL1 : This sub-program, when executed independently or opted from RESREL, calculates the failure rate of Composition resistor. Database file TRES1 is used to find the base failure rate,  $\lambda_b$ . Record no. 1 in MODE defines the  $\pi_E$  values for different environments.
- RREL2 : This is for Film resistor. If the specification is either MIL-R-39017 or MIL-R-22684, file TRES2 is used to find  $\lambda_b$ . Otherwise TRES3 is used for that purpose. Record no. 2 in MODE file is defined to give the different  $\pi_E$  values.
- RREL3 : For Power Film resistor. File TRES<sup>4</sup> is used to find  $\lambda_b$ . Record no. 3 in MODE defines the  $\pi_E$  values for different environments.
- RREL4 : For Resistor network (film type). File TREST is used to find the temperature factor  $\pi_T$ . Record no. 4 in MODE file gives the  $\pi_E$  values for different environments.
- RREL5 : For Wirewound, accurate resistor. File TRES5 is used to find  $\lambda_b$ . Record no. 5 in MODE shows

- the different  $\pi_E$  values.
- RREL6 : For Variable, Wirewound resistor. File TRES8 is used to find  $\lambda_b$ . Record no. 6 in MODE defines the different  $\pi_E$  values. File TRPTF is used to find  $\pi_{TAPS}$  of variable resistors.
- RREL7 : For Wirewound, Precision resistor. File TRES9 is used to find  $\lambda_b$ . Record no. 7 in MODE gives the  $\pi_E$  values for different environments. File TRPTF is used to find  $\pi_{TAPS}$ .
- RREL8 : For Wirewound, semiprecision resistor. File TRES10 is used to find  $\lambda_b$ . Record no. 8 in MODE defines the different  $\pi_E$  values. TRPTF is used to find  $\pi_{TAPS}$ .
- RREL9 : For Wirewound Power resistor. File TRES11 is used to find  $\lambda_b$ . Record no. 9 in MODE denotes the  $\pi_E$  values for different environments. TRPTF is used to find  $\pi_{TAPS}$ .
- RREL10 : For Variable nonwirewound resistor. File TRES12 is used to find  $\lambda_b$ . Record no. 10 in MODE gives the  $\pi_E$  values for different environments. TRPTF is also used to find  $\pi_{TAPS}$ .
- RREL11 : For Variable Composition resistor. File TRES13 is used to find  $\lambda_b$ . Record no. 11 in MODE shows the  $\pi_E$  factor for different environments.

- TRPTF is used to find  $\pi_{TAPS}$ .
- RREL12 : For Variable Film and Precision resistor. File TRES14 is used when the resistor specification is MIL-R-23285 and file TRES15 is used when the resistor specification is MIL-R-39023. Record no. 12 in MODE denotes the  $\pi_E$  factor for different environments.
- TREL1 : This sub-program, when executed independently or opted from TRNREL, calculate the failure rate of Silicon/Germanium (NPN/PNP) transistors. If the type of transistor is Silicon and NPN, file TRAN1 is used. If the selected transistor is Silicon and PNP type, file TRAN2 is used. If the type is Germanium and PNP, file TRAN3 and for Germanium and NPN type transistor, file TRAN4 is used. These TRAN database structures are used to find the base failure rate,  $\lambda_b$ , Record no. 13 in MODE is used to consider the environmental factor,  $\pi_E$ .
- TREL2 : This is for Silicon or Gallium Field Effect Transistor. File TRAN5 is used to find  $\lambda_b$ . Record no. 14 in MODE shows the values of  $\pi_E$  for different environments.

TREL3 : For Unijunction transistor. File TRAN6 is used to find  $\lambda_b$ . Record no. 15 gives the  $\pi_E$  values for different environments.

The values of different factors in the part failure models are stored in the sub-programs related to a particular component type. The values of part failure rate for different components in the circuit are calculated and stored in a database file named OUTPUT. In this tstructure all the influencing factors for different component types are also recorded. At the end of this file summation of all part failure rates i.e., the failure rate of the circuit, is stored. The details of various input factors for different component types are listed in figure A-2. The figure A-2 shows the general information needed for different component types. Variable names used of different input factors in this software are also given in the figure.

CAPACITORS CAPTYPE(VARIABLE NAME) →	TEMPERATURE	FAILURE RATE LEVEL	VALUE OF CAPACITORS	SPECIFICATION	MAXIMUM TEMPERATURE
	TEMP ↙	RATE LEVEL	C	SPEC	TMAX ↙
1. PAPER & PLASTIC FILM CAPACITORS	≤ 65°C ≤ 85°C ≤ 125°C	S, R, P, M, NON- ER, MIL-SPEC,	any value in μF	MIL-C-14157 MIL-C-19978	65°C 85°C 125°C
2. MICA CAPACITORS	≤ 125°C ≤ 150°C	S, R, P, M, NON- ER, MOLDED, LOWER NON-ER DIPPED,	pF	-	125°C 150°C
3. GLASS CAPACITORS	≤ 125°C ≤ 200°C	S, R, P, M, L, NON- ER, MIL-SPEC LOWER	pF	-	125°C 200°C
4. CERAMIC CAPACITORS	≤ 85°C ≤ 125°C	S, R, P, M, L, NON- ER, MIL-SPEC, LOWER	pF	-	85°C 125°C
5. TANTALUM ELECTRO- LYTIC CAPACITORS	≤ 125°C	S, R, P, M, L, LOWER	μF	-	125°C
6. ALUMINIUM ELECTRO- LYTIC CAPACITORS	≤ 125°C	S, R, P, M, NON-ER, L, MIL-SPEC, LOWER	μF	-	125°C
7. VARIABLE CERAMIC CAPACITORS	≤ 85°C ≤ 125°C	S, R, P, M, NON-ER, L, MIL-SPEC, LOWER	-	-	85°C 125°C
8. VARIABLE PISTON- TYPE CAPACITORS	≤ 125°C ≤ 150°C	S, R, P, M, L, NON-ER, MIL-SPEC, LOWER	-	-	125°C 150°C
9. VARIABLE AIR TRI- MMER CAPACITORS	≤ 85°C	S, R, P, M, L, NON-ER, MIL-SPEC, LOWER	-	-	85°C
10. VACUUM OR GAS CAPACITORS	≤ 85°C ≤ 100°C	S, R, P, M, L, NON-ER, MIL-SPEC, LOWER	-	-	85°C 100°C

\*CIRCUIT RESIS-  
RANCE(OHMS/VOLT);  
Variable name is  
CR; range 0.0 to  
any value

\*CONFIGURATION  
is FIXED or  
VARIABLE; varia-  
ble name is CF.

RES TYPE	(VARIABLE NAME) →	TEMP	TEMPERATURE	FAILURE RATE LEVEL (QUALITY LEVEL)	VALUE OF RESISTORS (IN KILO OHMS)	SPECIFICATION	No. of FILM RESISTORS USED	NO. OF TAPS	VRATIO
RES TYPE	(VARIABLE NAME) →	TEMP	TEMPERATURE	FAILURE RATE LEVEL (QUALITY LEVEL)	RESVALUE	SPEC	NR	TP	VRATIO
1.	COMPOSITION RESISTORS	≤ 120°C	≤ 120°C	S, R, P, M, LOWER, MIL-SPEC	≤ 10,000	-	-	-	-
2.	FILM RESISTORS	≤ 140°C ≤ 170°C	≤ 140°C ≤ 170°C	S, R, P, M, LOWER, MIL-SPEC	NO UPPER BOUND	MIL-R-39017 MIL-R-22684 MIL-R-55182 MIL-R-10509	-	-	-
3.	POWER FILM RESISTORS	≤ 210°C	≤ 210°C	MIL-SPEC, LOWER	NO UPPER BOUND	-	-	-	-
4.	RESISTOR NETWORK (FILM TYPE)	25-125°C	25-125°C	MIL-SPEC, LOWER	-	-	≤ 22	-	-
5.	WIREWOUND, ACCURATE RESISTORS	≤ 140°C	≤ 140°C	S, R, P, M, LOWER, MIL-SPEC	NO UPPER BOUND	-	-	-	-
6.	VARIABLE WIREWOUND RESISTORS	≤ 140°C	≤ 140°C	S, R, P, M, LOWER, MIL-SPEC	≤ 20	-	-	≤ 32	0.00-1.00
7.	WIREWOUND PRECISION RESISTORS	≤ 140°C	≤ 140°C	MIL-SPEC, LOWER	≤ 500	-	-	≤ 32	0.00-1.00
8.	WIREWOUND SEMIPRECISION RESISTORS	≤ 130°C	≤ 130°C	MIL-SPEC, LOWER	≤ 10	-	-	≤ 32	0.00-1.00
9.	WIREWOUND POWER RESISTORS	≤ 115°C	≤ 115°C	S, R, P, M, LOWER, MIL-SPEC	≤ 10	-	-	≤ 32	0.00-1.00
10.	VARIABLE NONWIREWOUND RESISTORS	≤ 140°C	≤ 140°C	S, R, P, M, LOWER, MIL-SPEC	≤ 1000	-	-	≤ 32	0.00-1.00
11.	VARIABLE COMPOSITION RESISTORS	≤ 115°C	≤ 115°C	MIL-SPEC, LOWER	≤ 1000	-	-	≤ 32	0.00-1.00
12.	VARIABLE FILM & PRECISION RESISTORS	≤ 170°C ≤ 115°C	≤ 170°C ≤ 115°C	MIL-SPEC, LOWER, MIL-SPEC, LOWER	NO UPPER BOUND	MIL-R-23285 MIL-R-39023	-	≤ 32	0.00-1.00

TRANSISTORS	TEMPERATURE	FAILURE RATE LEVEL (QUALITY LEVEL)	TYPE OF TRANSISTOR	APPLICATION	COMPLEXITY
TRANSTYPE (VARIABLE WAVE)	TEMP	RATELEVEL	TYPE	APPL	COMP
1. Si/Ge (NPN/PNP) TRANSISTORS	{ Si, * } < 160° { Ge, * } < 90°	JANTXV, JANTX, JAN, LOWER, PLASTIC	(Si, NPN), (Si, PNP), (Se, NPN), (Ge, PNP)	LINEAR, SWITCH, NOISE	SINGLE TRANSISTOR, DUAL (UNMATCHED), DUAL (MATCHED) DARLINGTON, DUAL EMITTER, MULTIPLE EMITTER, COMPLEMENTARY PAIR
2. SILICON/GALLIUM FIELD EFFECT TRANSISTORS	< 160°	JANTXV, JANTX, JAN, LOWER, PLASTIC, GaAs	-	LINEAR SWITCH, HIGH FREQUENCY LOW NOISE, DRIVER	DUAL COMPLEMENTARY, TETRODE
3. UNIJUNCTION TRANSISTORS	< 160°	JANTXV, JANTX, JAN, LOWER, PLASTIC	-	-	-

- \*  $V_{CE}/V_{CEO}$  range 0.0 to 100.0; variable name is S<sub>2</sub>
- \* POWER RATING (watts) range 0 to 200; variable name PWR

Fig. A-2 General Information for Input Variables of Components



appendix B

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APPENDIX -B  
Fig.B-1 PIE FACTOR FOR RESISTORS, TRANSISTORS, DIODES & CAPACITORS

COMPONENT TYPE	GB	SF	GF	NSB	NS	AIT	MP	MFF	MFA	GM	NH	NUU	AUT	NU	AIF	ARW	USL	AUF	ML	CL
RCOMP	1	1.0	2.9	4.0	5.2	2.8	8.5	8.6	13	8.3	13	14	5.7	12.0	5.7	19	25	11	29	490
RFILM	1	0.4	2.4	4.2	4.7	2.8	8.8	8.9	12	7.8	14	15	8.5	14.0	5.7	19	26	17	30	510
RPOWR	1	1.0	2.4	5.1	5.1	4.2	11.0	12.0	16	8.8	18	19	11.0	15.0	8.5	25	34	21	39	660
RNETW	1	1.0	2.4	4.2	4.7	2.8	8.8	8.9	12	7.8	14	15	8.5	14.0	5.7	19	26	17	30	510
RWIRW	1	1.5	2.4	5.2	5.2	6.0	12.0	12.0	17	9.8	18	20	20.0	16.0	12.0	27	36	40	41	610
RVWR	1	1.0	2.4	5.7	5.7	4.2	15.0	15.0	21	9.8	23	25	8.5	13.0	8.5	33	45	17	51	870
RWRP	1	1.0	2.4	8.4	8.4	5.0	24.0	24.0	34	11.0	37	39	11.0	14.0	10.0	53	71	21	81	1400
RWSP	1	1.0	2.4	7.0	7.0	5.0	17.0	0.0	0	16.0	27	29	0.0	0.0	10.0	38	0	0	0	0
RWPR	1	1.0	3.0	7.0	7.0	5.0	17.0	0.0	0	16.0	27	29	0.0	0.0	10.0	38	0	0	0	0
RVNW	1	1.0	2.9	5.7	5.7	5.0	18.0	18.0	25	11.0	27	29	11.0	15.0	10.0	39	53	21	61	1000
RVCOM	1	1.0	1.8	8.0	8.0	6.0	21.0	21.0	29	17.0	32	34	27.0	21.0	12.0	46	62	54	71	1200
RVFP	1	1.0	2.9	7.2	7.2	5.0	18.0	18.0	25	11.0	27	29	15.0	15.0	10.0	39	53	30	61	1000
TRAN	1	0.4	5.0	9.8	9.8	12.0	12.0	12.0	17	18.0	19	20	20.0	21.0	25.0	27	36	40	41	690
FET	1	0.6	4.0	6.0	8.6	12.0	12.0	12.0	17	18.0	19	20	20.0	21.0	25.0	27	36	40	41	690
UNIJ	1	1.0	4.0	9.3	9.3	12.0	12.0	12.0	17	18.0	19	20	20.0	21.0	25.0	27	36	40	41	690
DIOD	1	1.0	3.9	4.8	4.8	12.0	12.0	12.0	17	18.0	19	20	20.0	21.0	25.0	27	36	40	41	690
AVATHR	1	1.0	3.9	5.8	8.7	12.0	12.0	12.0	17	18.0	19	20	20.0	21.0	25.0	27	36	40	41	690
PAPER	1	1.0	2.4	4.4	5.7	4.0	9.2	9.3	13	7.8	14	15	11.0	13.0	8.0	20	27	21	31	530
MICA	1	1.0	2.4	5.0	6.2	4.2	11.0	11.0	15	8.8	16	17	17.0	15.0	8.5	23	31	34	36	610
GLASS	1	1.0	1.4	5.0	6.2	4.2	11.0	11.0	15	8.8	16	17	17.0	15.0	8.5	23	31	34	36	610
CERAM	1	0.8	1.6	5.0	5.5	8.5	11.0	11.0	15	7.8	16	18	17.0	12.4	17.0	24	32	34	36	610
TANT	1	0.8	2.4	4.4	4.9	6.0	9.2	9.3	13	7.8	14	15	11.0	13.0	12.0	20	27	21	31	530
ALELEC	1	1.0	2.4	5.8	6.7	8.5	12.0	12.0	17	12.0	19	20	21.0	13.0	17.0	27	36	42	41	690
VARCER	1	0.8	3.4	7.8	7.8	5.7	17.0	17.0	23	9.8	25	27	35.0	20.0	11.0	36	49	70	56	950
VARPIS	1	1.0	2.9	6.9	7.2	5.7	14.0	15.0	20	9.3	22	24	28.0	8.4	11.0	32	43	56	49	830
VARAIR	1	1.0	3.4	7.8	7.8	5.7	17.0	17.0	23	9.8	25	27	35.0	20.0	11.0	36	49	70	56	950
VACUUM	1	1.0	3.4	8.2	8.2	8.5	18.0	0.0	0	10.0	28	30	53.0	24.0	17.0	40	0	110	0	1800











STRUCTURE FOR FILE: C:TRES2 .DBF  
 NUMBER OF RECORDS: 00029  
 DATE OF LAST UPDATE: 10/27/87  
 PRIMARY USE DATABASE

FLD	NAME	TYPE	WIDTH	DEC
001	TEMP	N	004	
002	R1	N	007	005
003	R2	N	007	005
004	R3	N	007	005
005	R4	N	007	005
006	R5	N	007	005
007	R6	N	007	005
008	R7	N	006	004
009	R8	N	006	004
010	R9	N	006	004
011	R10	N	006	004
** TOTAL **			00071	

STRUCTURE FOR FILE: C:TRES3 .DBF  
 NUMBER OF RECORDS: 00035  
 DATE OF LAST UPDATE: 07/08/87  
 PRIMARY USE DATABASE

FLD	NAME	TYPE	WIDTH	DEC
001	TEMP	N	004	
002	R1	N	007	005
003	R2	N	007	005
004	R3	N	007	005
005	R4	N	007	005
006	R5	N	007	005
007	R6	N	006	004
008	R7	N	006	004
009	R8	N	006	004
010	R9	N	006	004
011	R10	N	006	004
** TOTAL **			00070	

STRUCTURE FOR FILE: C:TRES4 .DBF  
 NUMBER OF RECORDS: 00022  
 DATE OF LAST UPDATE: 10/27/87  
 PRIMARY USE DATABASE

FLD	NAME	TYPE	WIDTH	DEC
001	TEMP	N	004	
002	R1	N	006	004
003	R2	N	006	004
004	R3	N	006	004
005	R4	N	005	003
006	R5	N	005	003
007	R6	N	005	003
008	R7	N	005	003
009	R8	N	005	003
010	R9	N	005	003
011	R10	N	005	003
** TOTAL **			00058	

STRUCTURE FOR FILE: C:TRES5 .DBF  
 NUMBER OF RECORDS: 00029  
 DATE OF LAST UPDATE: 07/08/87  
 PRIMARY USE DATABASE

FLD	NAME	TYPE	WIDTH	DEC
001	TEMP	N	004	
002	R1	N	006	004
003	R2	N	006	004
004	R3	N	006	004
005	R4	N	006	004
006	R5	N	006	004
007	R6	N	006	004
008	R7	N	006	004
009	R8	N	006	004
010	R9	N	006	004
011	R10	N	006	004
** TOTAL **			00065	

STRUCTURE FOR FILE: C:FRAN1 .DBF  
 NUMBER OF RECORDS: 00029  
 DATE OF LAST UPDATE: 09/05/87  
 PRIMARY USE DATABASE

FLD	NAME	TYPE	WIDTH	DEC
001	TEMP	N	003	
002	R1	N	007	005
003	R2	N	007	005
004	R3	N	007	005
005	R4	N	007	005
006	R5	N	007	005
007	R6	N	006	004
008	R7	N	006	004
009	R8	N	006	004
010	R9	N	006	004
011	R10	N	006	004
** TOTAL **			00069	



\*\*\*\*\*RELECKT.PRG\*\*\*\*\*

```
SET TALK OFF
STORE 0 TO CHOICE
DO WHILE CHOICE<4
  CLEAR
  ?
  ?           M.E. DISSERTATION
  ?           TOPIC
  ?           RELIABILITY EVALUATION OF ELECTRONIC CIRCUITS
  ?           by
  ?           DEBASISH BASAK
  ?
  ? 1. CAPACITORS
  ? 2. DIODES
  ? 3. RESISTORS
  ? 4. TRANSISTORS
  ? 5. EXIT FROM THE SYSTEM
  ?
  ?
  INPUT 'Enter your choice (1-5) from above:' TO CHOICE
  IF CHOICE=1
    DO A:CAPREL
  ENDIF
  IF CHOICE=2
    DO A:DIODREL
  ENDIF
  IF CHOICE=3
    DO A:RESREL
  ENDIF
  IF CHOICE=4
    DO A:TRNREL
  ENDIF
ENDDO
RETURN
```

\*\*\*\*\*

\*\*\*\*\*CAPREL.PRG\*\*\*\*\*

SET TALK OFF

STORE 0 TO CAPTYPE

CLEAR

? 1. Paper & Plastic Film Capacitors'  
 ? 2. Mica Capacitors'  
 ? 3. Glass Capacitors'  
 ? 4. Ceramic Capacitors'  
 ? 5. Tantalum Electrolytic Capacitors'  
 ? 6. Aluminium Electrolytic Capacitors'  
 ? 7. Variable Ceramic Capacitors'  
 ? 8. Variable Piston Type Capacitors'  
 ? 9. Variable Air Trimmer Capacitors'  
 ? 10. Vacuum or Gas Capacitors'  
 ? 11.EXIT from the system'  
 ?  
 ?  
 ?

INPUT 'Enter the type of Capacitors (1-10) from above : ' TO CAPTYPE

IF CAPTYPE=1

DO A:CREL1

ENDIF

IF CAPTYPE=2

DO A:CREL2

ENDIF

IF CAPTYPE=3

DO A:CREL3

ENDIF

IF CAPTYPE=4

DO A:CREL4

ENDIF

IF CAPTYPE=5

DO A:CREL5

ENDIF

IF CAPTYPE=6

DO A:CREL6

ENDIF

IF CAPTYPE=7

DO A:CREL7

ENDIF

IF CAPTYPE=8

DO A:CREL8

ENDIF

IF CAPTYPE=9

DO A:CREL9

ENDIF

IF CAPTYPE=10

DO A:CREL10

ENDIF

RETURN

\*\*\*\*\*

\*\*\*\*\*RESREL.PRG\*\*\*\*\*

SET TALK OFF

STORE 0 TO RESTYPE

CLEAR

? 1. Composition Resistors'  
 ? 2. Film Resistors'  
 ? 3. Power Film Resistors'  
 ? 4. Resistor Network(Film type)'  
 ? 5. Wirewound,Accurate Resistors'  
 ? 6. Variable Wirewound Resistors'  
 ? 7. Variable Wirewound,Precision Resistors'  
 ? 8. Variable Wirewound,Semiprecision Resistors'  
 ? 9. Variable Wirewound,Power Resistors'  
 ? 10. Variable Non-wirewound,Power Resistors'  
 ? 11. Variable Composition Resistors'  
 ? 12. Variable Film & Precision Resistors'  
 ? 13. EXIT from the system'  
 ?  
 ?  
 ?

INPUT 'Enter the type of Resistors (1-12) from above:' TO RESTYPE

IF RESTYPE=1

DO A:RREL1

ENDIF

IF RESTYPE=2

DO A:RREL2

ENDIF

IF RESTYPE=3

DO A:RREL3

ENDIF

IF RESTYPE=4

DO A:RREL4

ENDIF

IF RESTYPE=5

DO A:RREL5

ENDIF

IF RESTYPE=6

DO A:RREL6

ENDIF

IF RESTYPE=7

DO A:RREL7

ENDIF

IF RESTYPE=8

DO A:RREL8

ENDIF

IF RESTYPE=9

DO A:RREL9

ENDIF

IF RESTYPE=10

DO A:RREL10

ENDIF

IF RESTYPE=11

DO A:RREL11

ENDIF

IF RESTYPE=12

DO A:RREL12

ENDIF

RETURN

\*\*\*\*\*

\*\*\*\*\*DIODREL.PRG\*\*\*\*\*

```

SET TALK OFF
STORE 0 TO DIODTYPE
CLEAR
?' 1. General Purpose (Si/Ge) Diodes'
?' 2. Avalanche & Zener Diodes'
?' 3. Thyristors'
?' 4. EXIT from the system'
?
?
?
  INPUT 'Enter the type of Diodes (1-3) from above:' TO DIODTYPE
IF DIODTYPE=1
  DO A:DREL1
ENDIF
IF DIODTYPE=2
  DO A:DREL2
ENDIF
IF DIODTYPE=3
  DO A:DREL3
ENDIF
RETURN

```

\*\*\*\*\*

\*\*\*\*\*TRNREL.PRG\*\*\*\*\*

```

SET TALK OFF
STORE 0 TO TRANSTYPE
CLEAR
?' 1. Si/Ge (NPN/PNP) Transistors'
?' 2. Silicon/Gallium Field Effect Transistors'
?' 3. Unijunction Transistors'
?' 4.EXIT from the system'
?
?
?
  INPUT 'Enter the type of Transistors (1-3) from above:' TO TRANSTYPE
IF TRANSTYPE=1
  DO A:TREL1
ENDIF
IF TRANSTYPE=2
  DO A:TREL2
ENDIF
IF TRANSTYPE=3
  DO A:TREL3
ENDIF
RETURN

```

\*\*\*\*\*

\*\*\*\*\*RREL2.PRG\*\*\*\*\*

```

IF RESTYPE=2
  STORE 0 TO TEMP
  STORE 0.000 TO RATIO
  STORE ' ' TO ENVIR
  STORE ' ' TO RATELEVEL
  STORE 0.00 TO RESVALUE
  @ 1,1 SAY 'GIVE TEMPERATURE' GET TEMP
  @ 2,1 SAY 'GIVE LOADRATIO' GET RATIO
  @ 3,1 SAY 'GIVE ENVIRONMENT' GET ENVIR
  @ 4,1 SAY 'FAILURE RATE LEVEL' GET RATELEVEL
  @ 5,1 SAY 'VALUE OF RESISTORS' GET RESVALUE
  STORE ' ' TO SPEC
  @ 6,1 SAY 'GIVE SPECIFICATION' GET SPEC
  READ
  STORE 5*INT(TEMP/5) TO X
  IF X<TEMP
    STORE X+5 TO X
  ENDIF
  STORE INT(X/5)+1 TO P
  STORE (1.0*INT(RATIO/0.1)*0.1) TO Y
  IF Y<RATIO
    STORE (Y+0.1) TO Y
  ENDIF
  IF Y<0.1
    STORE (Y+0.1) TO Y
  ENDIF
  STORE INT(Y/0.1) TO Z
  IF Z<10
    STORE STR(Z,1) TO Q
  ELSE
    STORE STR(Z,2) TO Q
  ENDIF
  STORE 'R'+Q TO A
  IF SPEC='MIL-R-39017'.OR.SPEC='MIL-R-22684'
    USE TRES2
    GOTO P
  STORE &A TO LANDAB
  ENDIF
  IF SPEC='MIL-R-10509'.OR.SPEC='MIL-R-55182'
    USE TRES3
    GOTO P
  STORE &A TO LANDAB
  ENDIF
  USE MODE
  GOTO 2
  STORE &ENVIR TO PIE
  IF RATELEVEL='S'
    STORE 0.03 TO PIQ
  ENDIF
  IF RATELEVEL='R'
    STORE 0.1 TO PIQ
  ENDIF
  IF RATELEVEL='P'
    STORE 0.3 TO PIQ
  ENDIF
  IF RATELEVEL='M'
    STORE 1.0 TO PIQ
  ENDIF

```

```

IF RATELEVEL='MIL-SPEC'
  STORE 5.0 TO P10
ENDIF
IF RATELEVEL='LOWER'
  STORE 15.0 TO P10
ENDIF
IF RESVALUE<=100000
  STORE 1.0 TO P1R
ENDIF
IF RESVALUE>100000
  STORE RESVALUE TO RES
  IF RES<=1000000
    STORE 1.1 TO P1R
  ENDIF
ENDIF
IF RESVALUE>1000000
  STORE RESVALUE TO RESV
  IF RESV<=10000000
    STORE 1.6 TO P1R
  ENDIF
ENDIF
IF RESVALUE>10000000
  STORE 2.5 TO P1R
ENDIF
STORE (LAMDAB*PIE*PIR*PI0) TO LAMDAP
CM='R'
USE OUTPUT
APPEND BLANK
REPLACE CMF WITH CM,RVAL WITH RESVALUE,LOAD WITH RATIO
REPLACE LAMB WITH LAMDAB,PE WITH PIE,PR WITH PIR
REPLACE P0 WITH PI0,LAMDA WITH LAMDAP
ENDIF
RETURN

```

\*\*\*\*\*

\*\*\*\*\*RREL3.PRG\*\*\*\*\*

```

IF RESTYPE=3
  STORE 0 TO TEMP
  STORE 0.000 TO RATIO
  STORE ' ' TO ENVIR
  STORE ' ' TO RATELEVEL
  STORE 0.00 TO RESVALUE
  @ 1,1 SAY 'GIVE TEMPERATURE' GET TEMP
  @ 2,1 SAY 'GIVE LOADRATIO' GET RATIO
  @ 3,1 SAY 'GIVE ENVIRONMENT' GET ENVIR
  @ 4,1 SAY 'FAILURE RATE LEVEL' GET RATELEVEL
  @ 5,1 SAY 'VALUE OF RESISTORS' GET RESVALUE
  READ
  STORE 5*INT(TEMP/5) TO X
  IF X<TEMP
    STORE X+5 TO X
  ENDIF
  STORE INT(X/5)+1 TO P
  STORE (1.0*INT(RATIO/0.1)+0.1) TO Y

```

```

IF Y<RATIO
  STORE (Y+0.1) TO Y
ENDIF
IF Y<0.1
  STORE (Y+0.1) TO Y
ENDIF
STORE INT(Y/0.1) TO Z
IF Z<10
  STORE STR(Z,1) TO Q
ELSE
  STORE STR(Z,2) TO Q
ENDIF
STORE 'R'+Q TO A
USE TRES4
GOTO P
STORE &A TO LAMDAB
USE MODE
GOTO 3
STORE &ENVIR TO PIE
IF RATELEVEL='MIL-SPEC'
  STORE 1.0 TO PIQ
ENDIF
IF RATELEVEL='LOWER'
  STORE 3.0 TO PIQ
ENDIF
IF RESVALUE<=100
  STORE 1.2 TO PIR
ENDIF
IF RESVALUE>100
  STORE RESVALUE TO RESV
  IF RESV<=100000
    STORE 1.0 TO PIR
  ENDIF
ENDIF
IF RESVALUE>100000
  STORE RESVALUE TO RES
  IF RES<=1000000
    STORE 1.3 TO PIR
  ENDIF
ENDIF
IF RESVALUE>1000000
  STORE 3.5 TO PIR
ENDIF
STORE (LAMDAB*PIE*PIR*PIQ) TO LAMDAP
CM='R'
USE OUTPUT
APPEND BLANK
REPLACE CMF WITH CM,LOAD WITH RATIO,RVAL WITH RESVALUE
REPLACE LAMB WITH LAMDAB,PE WITH PIE,PR WITH PIR
REPLACE PO WITH PIQ,LAMDA WITH LAMDAP
ENDIF
RETURN

```

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\*\*\*\*\*RRREL5.PRG\*\*\*\*\*

```

IF RESTYPE=5
  STORE 0 TO TEMP
  STORE 0.000 TO RATIO
  STORE ' ' TO ENVIR
  STORE ' ' TO RATELEVEL
  STORE 0.00 TO RESVALUE
  @ 1,1 SAY 'GIVE TEMPERATURE' GET TEMP
  @ 2,1 SAY 'GIVE LOADRATIO' GET RATIO
  @ 3,1 SAY 'GIVE ENVIRONMENT' GET ENVIR
  @ 4,1 SAY 'FAILURE RATE LEVEL' GET RATELEVEL
  @ 5,1 SAY 'VALUE OF RESISTORS' GET RESVALUE
  READ
  STORE 5*INT(TEMP/5) TO X
  IF X<TEMP
    STORE X+5 TO X
  ENDIF
  STORE INT(X/5)+1 TO P
  STORE (1.0*INT(RATIO/0.1)*0.1) TO Y
  IF Y<RATIO
    STORE (Y+0.1) TO Y
  ENDIF
  IF Y<0.1
    STORE (Y+0.1) TO Y
  ENDIF
  STORE INT(Y/0.1) TO Z
  IF Z<10
    STORE STR(Z,1) TO Q
  ELSE
    STORE STR(Z,2) TO Q
  ENDIF
  STORE 'R'+Q TO A
  USE TRESS
  GOTO P
  STORE &A TO LAMDAB
  USE MODE
  GOTO 5
  STORE &ENVIR TO PIE
  IF RATELEVEL='S'
    STORE 0.03 TO P10
  ENDIF
  IF RATELEVEL='R'
    STORE 0.1 TO P10
  ENDIF
  IF RATELEVEL='F'
    STORE 0.3 TO P10
  ENDIF
  IF RATELEVEL='M'
    STORE 1.0 TO P10
  ENDIF
  IF RATELEVEL='MIL-SPEC'
    STORE 5.0 TO P10
  ENDIF
  IF RATELEVEL='LOWER'
    STORE 15.0 TO P10
  ENDIF
  IF RESVALUE<=10000
    STORE 1.0 TO PIR

```



```
ENDIF
IF RESVALUE>10000
  STORE RESVALUE TO RESV
  IF RESV<=100000
    STORE 1.7 TO PIR
  ENDIF
ENDIF
IF RESVALUE>100000
  STORE RESVALUE TO RES
  IF RES<=1000000
    STORE 3.0 TO PIR
  ENDIF
ENDIF
IF RESVALUE>1000000
  STORE 5.0 TO PIR
ENDIF
STORE (LAMBDA*PIE*PIR*PIQ) TO LAMDAF
CM='R'
USE OUTPUT
APPEND BLANK
REPLACE CMF WITH CM,LOAD WITH RATIO,RVAL WITH RESVALUE
REPLACE LAMB WITH LAMBDA,PE WITH PIE,PR WITH PIR,PO WITH PIQ
REPLACE LAMDA WITH LAMDAF
ENDIF
RETURN
```

\*\*\*\*\*

\*\*\*\*\*TREL1.PRG\*\*\*\*\*

```

IF TRANSTYPE=1
  STORE 0 TO TEMP
  STORE 0.000 TO RATIO
  STORE ' ' TO ENVIR
  STORE ' ' TO RATELEVEL
  STORE 0.000 TO PWR
  @ 1,1 SAY 'GIVE TEMPERATURE' GET TEMP
  @ 2,1 SAY 'GIVE LOADRATIO' GET RATIO
  @ 3,1 SAY 'GIVE ENVIRONMENT' GET ENVIR
  @ 4,1 SAY 'GIVE FAILURE RATELEVEL' GET RATELEVEL
  STORE ' ' TO TYPE
  STORE ' ' TO COMP
  STORE ' ' TO APPL
  STORE 0.00 TO S2
  @ 5,1 SAY 'Si/Ge,NPN/PNP' GET TYPE
  @ 6,1 SAY 'COMPLEXITY' GET COMP
  @ 7,1 SAY 'APPLICATION' GET APPL
  @ 8,1 SAY '(Applied Vce/Rated Vceo)*100' GET S2
  @ 9,1 SAY 'POWER RATING' GET PWR
  READ
  IF TYPE='Si,NPN'
    USE TRAN1
    STORE (1.0*INT(RATIO/0.1)*0.1) TO Y
    IF Y<RATIO
      STORE (Y+0.1) TO Y
    ENDIF
    STORE INT(Y/0.1) TO Z
    IF Z<10
      STORE STR(Z,1) TO X
    ELSE
      STORE STR(Z,2) TO X
    ENDIF
    STORE 'R'+X TO A
    IF TEMP=0
      GOTO 1
    ENDIF
    IF TEMP>0
      STORE TEMP TO TE
      IF TE<=10
        GOTO 2-
      ENDIF
    ENDIF
    IF TEMP>10
      STORE TEMP TO TEM
      IF TEM<=20
        GOTO 3
      ENDIF
    ENDIF
    IF TEMP>20
      STORE TEMP TO T
      IF T<=25
        GOTO 4
      ENDIF
    ENDIF
    IF TEMP>25
      STORE TEMP TO TE1
      IF TE1<=30
        GOTO 5
      ENDIF
  ENDIF

```

```
ENDIF
IF TEMP>30
  STORE TEMP TO TE2
  IF TE2<=40
    GOTO 6
  ENDIF
ENDIF
IF TEMP>40
  STORE TEMP TO TE3
  IF TE3<=50
    GOTO 7
  ENDIF
ENDIF
IF TEMP>50
  STORE 5*INT(TEMP/5) TO X
  IF X<TEMP
    STORE X+5 TO X
  ENDIF
  STORE INT(X/5)+1 TO P
  STORE (P-4) TO P
  GOTO P
ENDIF
STORE &A TO LANDAB
ENDIF
IF TYPE='S1,PNP'
  STORE (1.0*INT(RATIO/0.1)*0.1) TO Y
  IF Y<RATIO
    STORE (Y+0.1) TO Y
  ENDIF
  IF Y<0.1
    STORE (Y+0.1) TO Y
  ENDIF
  STORE INT(Y/0.1) TO Z
  IF Z<10
    STORE STR(Z,1) TO @
  ELSE
    STORE STR(Z,2) TO @
  ENDIF
  STORE 'R'+@ TO A
  USE TRANZ
  IF TEMP=0
    GOTO 1
  ENDIF
  IF TEMP>0
    STORE TEMP TO TE
    IF TE<=10
      GOTO 2
    ENDIF
  ENDIF
  IF TEMP>10
    STORE TEMP TO TEM
    IF TEM<=20
      GOTO 3
    ENDIF
  ENDIF
ENDIF
```

```

IF TEMP>20
  STORE TEMP TO T
  IF T<=25
    GOTO 4
  ENDIF
ENDIF
IF TEMP>25
  STORE TEMP TO TE1
  IF TE1<=30
    GOTO 5
  ENDIF
ENDIF
STORE &A TO LAMDAB
ENDIF
IF TYPE='Ge,PNP'
  STORE (1.0*INT(RATIO/0.1)*0.1) TO Y
  IF Y<RATIO
    STORE (Y+0.1) TO Y
  ENDIF
  IF Y<0.1
    STORE (Y+0.1) TO Y
  ENDIF
  STORE INT(Y/0.1) TO Z
  IF Z<10
    STORE STR(Z,1) TO Q
  ELSE
    STORE STR(Z,2) TO Q
  ENDIF
  STORE 'R'+Q TO A
  USE TRANS
  STORE 5*INT(TEMP/5) TO X
  IF X<TEMP
    STORE X+5 TO X
  ENDIF
  STORE INT(X/5)+1 TO P
  GOTO P
  STORE &A TO LAMDAB
ENDIF
IF TYPE='Ge,NPN'
  STORE (1.0*INT(RATIO/0.1)*0.1) TO Y
  IF Y<RATIO
    STORE (Y+0.1) TO Y
  ENDIF
  IF Y<0.1
    STORE (Y+0.1) TO Y
  ENDIF
  STORE INT(Y/0.1) TO Z
  IF Z<10
    STORE STR(Z,1) TO Q
  ELSE
    STORE STR(Z,2) TO Q
  ENDIF
  STORE 'R'+Q TO A
  USE TRAN4
  STORE 5*INT(TEMP/5) TO X
  IF X<TEMP
    STORE X+5 TO X
  ENDIF

```

```
STORE INT(X/5)+1 TO P
GOTO P
STORE &A TO LAMDA B
ENDIF
USE MODE
GOTO 13
STORE &ENVIR TO PIE
IF RATELEVEL='LOWER'
  STORE 6.0 TO PIO
ENDIF
IF RATELEVEL='JANTXV'
  STORE 0.12 TO PIO
ENDIF
IF RATELEVEL='JANTX'
  STORE 0.24 TO PIO
ENDIF
IF RATELEVEL='JAN'
  STORE 1.2 TO PIO
ENDIF
IF RATELEVEL='PLASTIC'
  STORE 12.0 TO PIO
ENDIF
IF COMP='SINGLE TRANSISTOR'
  STORE 1.0 TO PIC
ENDIF
IF COMP='DUAL (UNMATCHED)' .OR. COMP='COMPLEMENTARY PAIR'
  STORE 0.7 TO PIC
ENDIF
IF COMP='DUAL (MATCHED)' .OR. COMP='MULTIPLE EMITTER'
  STORE 1.2 TO PIC
ENDIF
IF COMP='DARLINGTON'
  STORE 0.8 TO PIC
ENDIF
IF COMP='DUAL EMITTER'
  STORE 1.1 TO PIC
ENDIF
IF APPL='LINEAR'
  STORE 1.5 TO PIA
ENDIF
IF APPL='SWITCH'
  STORE 0.7 TO PIA
ENDIF
IF APPL='LOW NOISE'
  STORE 15.0 TO PIA
ENDIF
IF S2>=25
  PIS2=0.14*(10)**(0.0133*S2)
ENDIF
IF S2<25
  PIS2=0.3
ENDIF
IF PWR<=1.0
  STORE 1.0 TO PIR
ENDIF
```

```

IF PWR>1.0
  STORE PWR TO P1
  IF P1<=5.0
    STORE 1.5 TO PIR
  ENDIF
ENDIF
IF PWR>5.0
  STORE PWR TO P2
  IF P2<=20.0
    STORE 2.0 TO PIR
  ENDIF
ENDIF
IF PWR>20.0
  STORE PWR TO P3
  IF P3<=50.0
    STORE 2.5 TO PIR
  ENDIF
ENDIF
IF PWR>50.0
  STORE PWR TO P4
  IF P4<=200.0
    STORE 5.0 TO PIR
  ENDIF
ENDIF
LAMDAF=LAMDA*(PIE*PIA*PIQ*PIS2*PIC)
CM='T'
USE OUTPUT
APPEND BLANK
REPLACE CM WITH CM,LOAD WITH RATIO,LAMB WITH LAMDA
REPLACE PE WITH PIE,PA WITH PIA,PQ WITH PIQ,PS2 WITH PIS2
REPLACE PC WITH PIC,PR WITH PIR,LAMDA WITH LAMDAF
ENDIF
RETURN

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